

Emerging BaZrS₃ and Ba(Zr,Ti)S₃ Chalcogenide Perovskite Solar Cells: A Numerical Approach Toward Device Engineering and Unlocking Efficiency

Eupsy Navis Vincent Mercy, Dhineshkumar Srinivasan, and Latha Marasamy*



Cite This: *ACS Omega* 2024, 9, 4359–4376



Read Online

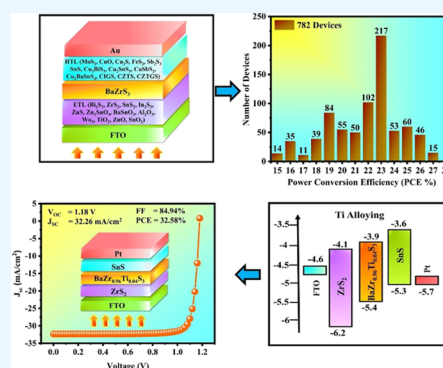
ACCESS |

Metrics & More

Article Recommendations

Supporting Information

ABSTRACT: BaZrS₃ chalcogenide perovskites have emerged as a promising absorber due to their exceptional properties. However, there are no experimental reports on the applicability of BaZrS₃ in photovoltaics. Thus, theoretical knowledge of device structure engineering is essential for its successful fabrication. In this regard, we have proposed various BaZrS₃ device configurations by altering 12 electron transport layers (ETLs) in combination with 13 hole transport layers (HTLs) using SCAPS-1D, wherein a total of 782 devices are simulated by tuning the thickness, carrier concentration, and defect density of BaZrS₃, ETLs, and HTLs. Interestingly, the absorber's thickness optimization enhanced the absorption in the device by 2.31 times, elevating the generation rate of charge carriers, while the increase in its carrier concentration boosted the built-in potential from 0.8 to 1.68 V, reducing the accumulation of charge carriers at the interfaces. Notably, on further optimization of ETL and HTL combinations, the best power conversion efficiency (PCE) of 28.08% is achieved for FTO/ZrS₂/BaZrS₃/SnS/Au, occurring due to the suppressed barrier height of 0.1 eV at the ZrS₂/BaZrS₃ interface and degenerate behavior of SnS, which increased charge carrier transportation and conductivity of the devices. Upon optimizing the work function, an ohmic contact is achieved for Pt, boosting the PCE to 28.17%. Finally, the impact of Ti alloying on BaZrS₃ properties is examined on the champion FTO/ZrS₂/BaZrS₃/SnS/Pt device where the maximum PCE of 32.58% is obtained for Ba(Zr_{0.96}Ti_{0.04})S₃ at a thickness of 700 nm due to extended absorption in the NIR region. Thus, this work opens doors to researchers for the experimental realization of high PCE in BaZrS₃ devices.



1. INTRODUCTION

With the increase in global energy demand, extensive efforts have been made to address the depletion of fossil fuels like coal, oil, and natural gas. Thus, the quest for enduring eco-friendly energy solutions to meet the escalating demand has become crucial. Amidst these pursuits, solar energy conversion employing photovoltaic (PV) technology is a sustainable and environmentally conscious approach to generating electricity.¹ Over the past decade, lead halide perovskites (MAPbX₃ where X = I, Br, Cl) have revolutionized the development of PV materials. They demonstrated a power conversion efficiency (PCE) of 3.8% in 2009² by using liquid electrolytes as a hole transport layer (HTL).³ The PCE was improved to 9.7% in 2012 by replacing the HTL with the solid-state spiro-OMeTAD. Within a few years, the lead halide perovskites emerged as a promising optoelectronic material with its unprecedented rate of increase in PCE up to 26.1% in 2023.⁴ Despite the enhanced performance, the toxicity of lead and instability of halides in humidity, heat, and light hinder their pace of commercialization. As a result, researchers have been exploring lead-free perovskite materials to address these environmental concerns. Various materials are being developed as alternatives to lead-based perovskites. To be specific,

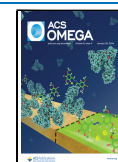
perovskites based on tin (Sn) and germanium (Ge) such as MASnI₃, CsSnI₃, FASnI₃, CsGeI₃, MAGEI₃, FAGEI₃, and CsSn_{0.5}Ge_{0.5}I₃ have emerged as promising alternatives due to their similar isoelectronic (s²p²) configuration, high carrier mobility, nontoxicity, and narrow band gaps. Although there are some challenges when it comes to stability, such as Sn²⁺ and Ge²⁺ ions being easily oxidized and converting to Sn⁴⁺ and Ge⁴⁺ when exposed to ambient atmosphere, the high cost and lack of Ge in the earth's crust also limit its applicability.⁵ Certainly, researchers have found some alternative solutions. For instance, they have introduced trivalent cations like Bi³⁺ and Sb³⁺ instead of Pb²⁺ ions. However, the PCE achieved is still much lower than lead halide perovskites due to their low-dimensional structure, which results in unfavorable optoelectronic properties. To overcome these challenges, halide double perovskites (HDPs) have been developed with a structure

Received: September 3, 2023

Revised: December 18, 2023

Accepted: December 22, 2023

Published: January 17, 2024



similar to $A_2B^+B^{3+}X_6$, replacing Pb^{2+} with eco-friendly Bi^{3+} while maintaining a three-dimensional (3D) structure. This innovative solution involves replacing two Pb^{2+} ions with one B^+ ion and one B^{3+} ion.⁶ Some notable examples of these HDPs are $Cs_2AgBiBr_6$, $Cs_2NaBiCl_6$, $(CH_3NH_3)_2AgBiBr_6$, and $(CH_3NH_3)_2KBiCl_6$, which have recently emerged as highly promising materials. While HDPs have great potential, their efficiency is limited by large charge carrier effective masses, high band gap (>2 eV), and weak charge carrier transport capabilities. Research has been focused on exploring antimony-based perovskite materials (such as $Cs_2SbCuCl_6$, $Cs_4SbCuCl_{12}$, $Cs_2SbAgCl_6$, Cs_2SbAgI_6 , and $Cs_2SbAgBr_6$) as they offer unique attributes like stability at high temperatures and exceptional charge carrier conductivity. However, their wide band gaps, high binding energies, and high carrier effective mass limit their performance.⁷ Apart from perovskites, researchers are also exploring other light absorbers such as ternary II–IV–N₂ nitrides ($ZnSnN_2$),^{8,9} binary halides (InI^{10} and BiI_3^{11}), ABZ_2 chalcogenides ($AgBiS_2$,¹² $NaBiS_2$,¹³ and $NaSbS_2$ ¹⁴), Bi-based chalcogenides ($BiOI$,¹⁵ $BiSI$,¹⁶ $Bi_{19}S_{27}Br_3$,¹⁷ and $Bi_{13}S_{18}I_2$ ¹⁷), Sb-based chalcogenides ($SbSI$,^{18,19} $SbSeI$,²⁰ and $SbBiSI$ ²¹), Pb-based chalcogenides ($Pb_4S_3Br_2$ ²² and $Pb_2SbS_2I_3$ ²³), Ag-based chalcogenides ($Ag_3BiI_{6-2x}S_x$),²⁴ Sn-based chalcogenides ($Sn_2SbS_2I_3$),²⁵ hybrid organic–inorganic metal chalcogenides ($MASbSI_2$ ²⁶ and $MA_3Bi_2I_{9-2x}S_x$ ²⁷), I₂–II–IV–VI₄ semiconductors ($Cu_2BaSnSe_4$,²⁸ Cu_2SrSnS_4 ²⁹), and II–V semiconductors (Zn_3P_2).^{30–32} Despite their promise, these emerging absorbers have exhibited PCEs below 8%. Therefore, we are urged to discover new materials that can retain the extraordinary properties of lead halide perovskites while overcoming the aforementioned limitations.

In this concern, chalcogenide perovskites emerged as an alternative novel material due to their nontoxicity and high stability. They grabbed the limelight in 2015 when Sun et al. theoretically screened 18 ABX_3 ($A = Ba, Sr, Ca$; $B = Ti, Zr, Hf$; $X = S, Se$) compounds to be promising for optoelectronic applications.³³ Among them, $BaZrS_3$ is considered to be ideal from the standpoint of the direct band gap of 1.7 eV,³⁴ high absorption coefficient $>10^5$ cm⁻¹ at photon energy larger than 1.97 eV (<700 nm),³⁵ elevated carrier mobility of 30 cm²/(V s) with p-type conductivity,³⁶ and exceptional stability toward moisture, light, and temperature.³⁷ Prior research indicates that the performance of $BaZrS_3$ can be improved further by alloying with both titanium (Ti) and selenium (Se). So far, Ti alloying has proven to be more productive due to its effective band gap reduction with less atom %. Specifically, Meng et al. reported that the band gap obtained for 0.1 atom % Ti alloying can only be accomplished at 1 atom % of Se alloying.³⁸ However, no experimental reports related to the applicability of $BaZrS_3$ and $Ba(Zr,Ti)S_3$ in PV exist due to its challenging synthesis temperatures exceeding 900 °C, limiting its feasibility and exploration of chalcogenide perovskites.³⁹

Nevertheless, recent advancements have resulted in a reduction in the operating temperature required to synthesize $BaZrS_3$. For example, Comparotto et al. reported the synthesis of $BaZrS_3$ thin films, employing a sputter-sulfurization approach with a process temperature below 600 °C.⁴⁰ Similarly, Nag et al. detailed their work on $BaZrS_3$ nanocrystals (powder) synthesis at 600 °C, followed by the formulation of an ink and film-coating process, while Yu et al. demonstrated the synthesis of $BaZrS_3$ thin films at an even lower temperature of 500 °C by modifying the chemical reaction pathway.⁴¹ Interestingly, Yang et al. and Zilevu et al. reported colloidal

synthesis of $BaZrS_3$ nanopowders at an impressive temperature below 350 °C, underscoring the potential of solution-based processing of $BaZrS_3$.^{42,43} Most recently, in 2023, Vincent et al. introduced a groundbreaking approach for the solution processing of direct $BaZrS_3$ thin films. This method involves heat treatment of precursor thin films in a sulfur-containing atmosphere at modest temperatures ranging from 500 to 575 °C.⁴⁴ These reports are a major accomplishment in producing $BaZrS_3$. They used processing temperatures similar to those of traditional absorbers, which is a significant advancement. These developments have opened new opportunities for creating effective $BaZrS_3$ devices. Therefore, to predict the device performance, we utilized a solar cell capacitance simulator in a one dimension (SCAPS-1D) theoretical tool to study the influence of each layer's parameters, interfacial defects, stability, and band alignment of the device by saving the time and cost before investing into fabrication.⁴⁵ Moreover, SCAPS-1D is a highly reliable software as the simulation results are consistent with the experimental work.⁴⁶

Researchers recently employed $BaZrS_3$ and $Ba(Zr,Ti)S_3$ as absorbers in thin-film devices and studied their influence using SCAPS-1D.^{37,47,48} However, a comprehensive study on the device engineering and properties of $BaZrS_3$ and $Ba(Zr,Ti)S_3$ is scarce, creating more room to discover and understand the potential of these absorbers in thin-film devices. Also, choosing the right electron transport layers (ETLs) and HTLs is crucial in creating efficient devices. ETLs are particularly important as they help extract and transfer photogenerated electrons while blocking holes. An ideal ETL should possess several vital attributes, including a wide band gap that facilitates high light transmission, perfect energy levels, cost-effectiveness, high electron mobility for efficient electron injection and transport, and photochemical and thermal stability. Organic materials and polymers are lead halide perovskites, the most widely used ETLs. However, these materials tend to be expensive and less stable. Interestingly, inorganic ETLs are a promising alternative due to their high stability, easy preparation process, cost-effectiveness, and excellent electronic properties.^{49,50} Considering these advantages, we have carefully curated a list of 12 promising inorganic ETLs, including Bi_2S_3 ,^{51,52} ZrS_2 ,^{53,54} SnS_2 ,⁵⁵ In_2S_3 ,⁵⁶ ZnS ,⁵⁶ Zn_2SnO_4 ,⁵⁷ $BaSnO_3$,⁵⁸ Al_2O_3 ,^{59,60} WO_3 ,⁵⁹ TiO_2 ,⁶¹ ZnO ,⁶¹ and SnO_2 ⁶¹ for our simulation. On the other hand, the choice of HTLs significantly affects the device's performance, durability, and production cost. While small-molecule HTLs can enhance the device's performance, they often suffer from stability issues. In contrast, polymeric HTLs offer stability at high temperatures and compatibility with other materials, but their poor optoelectronic properties hinder efficiency. Additionally, commonly used organic HTLs like Spiro-MeOTAD are expensive and unstable in ambient conditions. Interestingly, inorganic HTLs offer numerous advantages, such as outstanding stability, high hole mobility, low cost, and easy preparation techniques, and have proven to be promising for achieving stable and efficient device performance.^{6,62} In this context, we have selected 13 HTLs, including MoS_2 ,⁶³ CuO ,⁶⁴ Cu_2S ,⁶⁵ FeS_2 ,⁶⁶ Sb_2S_3 ,⁶⁷ SnS ,⁶⁸ Cu_3BiS_3 ,⁶⁹ Cu_2SnS_3 ,⁷⁰ $CuSbS_2$,⁷¹ Cu_2BaSnS_4 ,⁷² $CuInGaS_2$,⁷³ Cu_2ZnSnS_4 ,⁷⁴ and $Cu_2ZnSn_{1-x}Ge_xS_4$.⁷⁴ Thus, our work embarks on modeling 782 thin-film devices employing $BaZrS_3$ as the absorber, varying 13 HTLs and 12 ETLs to elucidate an ideal device structure. The material properties have been studied extensively by varying the thickness, carrier concentration, and defect density of each ETL with 13 HTLs

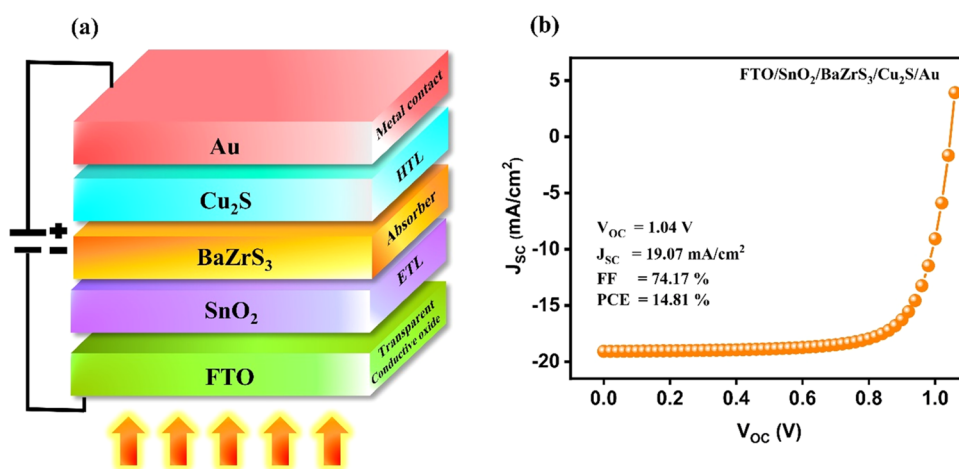


Figure 1. (a) Initial device structure and (b) J - V characteristics of the emerging BaZrS₃ chalcogenide perovskite device.

Table 1. SCAPS-1D Input Parameters of the Initial Device Structure

parameter	FTO	SnO ₂	BaZrS ₃	Cu ₂ S
thickness (nm)	10	30	500	50
band gap E_g (eV)	3.50	3.50	1.70	1.21
affinity χ (eV)	4.00	4.00	4.10	4.45
dielectric permittivity ϵ_r	9.0	9.0	9.6	30
conduction band effective density of states N_C (cm ⁻³)	2.2×10^{18}	2.20×10^{17}	2.2×10^{18}	1.00×10^{19}
valence band effective density of states N_V (cm ⁻³)	1.8×10^{19}	2.20×10^{16}	1.8×10^{19}	6.15×10^{19}
electron thermal velocity (cm/s)	1×10^7	1×10^7	1×10^7	1×10^7
hole thermal velocity (cm/s)	1×10^7	1×10^7	1×10^7	1×10^7
electron mobility (cm ² /(V s))	2×10^1	2.00×10^{01}	1.10×10^{-02}	5.00×10^1
hole mobility (cm ² /(V s))	1×10^1	1.00×10^{01}	3.90×10^{-02}	4.00×10^0
donor density N_D (cm ⁻³)	1×10^{18}	1×10^{18}	0	0
acceptor density N_A (cm ⁻³)	0	0	1×10^{15}	7×10^{16}
defect density N_T (cm ⁻³)	1×10^{15}	1×10^{15}	1×10^{10}	1×10^{13}
references	80	81	47,48	82

to investigate their suitability for emerging BaZrS₃-based devices. Moreover, the role of back contacts is meticulously examined by tuning the metal electrode work functions. Furthermore, we studied the influence of Ti alloying, with its concentration ranging from 1 to 4 atom % in the BaZrS₃ absorber for the device that attained the highest PCE.⁷⁵ To this end, an array of analyses, including current density–voltage (J - V), capacitance–voltage (C - V), quantum efficiency (QE), electric field distributions, generation profiles, and recombination profiles, have been utilized to gain a broader knowledge of the functioning of devices. On top of that, the role of band alignment between the absorber and transporting layers was also examined using the energy band diagram extracted from SCAPS-1D. Thus, we firmly believe that our work creates a significant impact among researchers worldwide by providing a better direction for understanding the performance of BaZrS₃ and Ba(Zr,Ti)S₃ and facilitates the research community in selecting cost-effective and efficient devices for commercialization as the wheel of development rolls on.

2. COMPUTATIONAL STRATEGY AND DEVICE DESCRIPTION

One-dimensional Solar Cell Capacitance Simulator (SCAPS-1D) is a well-known software program developed by Mark Burgelmann at the University of Ghent in Belgium to predict the device performance concerning the characteristics of each

layer and interface. This software offers numerous advantages, such as conducting performance analysis at up to seven levels to perform comprehensive and batch analyses.⁷⁶ The theoretical calculation relies on three fundamental equations, namely, Poisson's equation, the carrier continuity equation, and the drift-diffusion equation, which are as follows⁷⁷

$$\frac{\partial^2 \varphi}{\partial x^2} = \frac{q}{\epsilon} (n - p) \quad (1)$$

$$\frac{\partial n}{\partial t} = \frac{1}{q} \frac{\partial J_n}{\partial x} + (G - R), \quad \frac{\partial p}{\partial t} = -\frac{1}{q} \frac{\partial J_p}{\partial x} + (G_p - R_p) \quad (2)$$

$$J_n = qD_n \frac{\partial n}{\partial x} - q\mu_n n \frac{\partial \varphi}{\partial x}, \quad J_p = qD_p \frac{\partial p}{\partial x} - q\mu_p p \frac{\partial \varphi}{\partial x} \quad (3)$$

where q is the charge of electrons (C), p is the concentration of holes (cm⁻³), ϵ is the dielectric constant, n is the concentration of electrons (cm⁻³), φ is the electric potential (V), R is the carrier recombination rate (cm⁻³ s⁻¹), G is the carrier generation rate (cm⁻³ s⁻¹), J_p is the current density of holes (mA/cm²), J_n is the current density of electrons (mA/cm²). D_n and D_p refer to coefficients of electrons and hole diffusion (cm²/s), respectively, while μ_n and μ_p are the mobilities of electrons and holes (cm²/(V s)).^{77,78}

In this work, we initially designed a base device with superstrate configuration FTO/SnO₂/BaZrS₃/Cu₂S/Au, as shown in Figure 1a, using SCAPS-1D (version 3.3.10). The light enters through fluorine-doped tin oxide (FTO) and gets transmitted through the SnO₂ ETL to the absorber. Due to the p–n junction's built-in potential, charge carriers are generated, separated, and collected at the respective contacts.⁷⁹ A summary of the simulation's initial device parameters for FTO, SnO₂, BaZrS₃, and Cu₂S is shown in Table 1. All of the analyses were performed under AM 1.5G (100 W cm⁻², one sun) spectral irradiance, and the operational temperature of devices was maintained at 300 K.

To begin with, the initial device performance (Section 3.1) is represented in the *J*–*V* curve (Figure 1b). After that, the influence of varying the thickness, carrier concentration, and defect density of ETL, absorber, and HTL is studied and reported in Section 3.2. The corresponding device parameters, such as open-circuit voltage (*V*_{oc}), short-circuit current density (*J*_{sc}), fill factor (FF), and PCE, are obtained. After optimizing each layer in the initial device, the impact of different ETLs and HTLs on the device's PCE is explained in Section 3.3. A schematic representation of energy band diagrams and the 156 devices that achieved the highest PCE for each ETL and HTL combination is shown in Figure 4 and Table 2, respectively. In

Table 2. Influence of Metal Work Function on PV Parameters

metal contacts	work function (eV)	<i>V</i> _{oc} (V)	<i>J</i> _{sc} (mA/cm ²)	FF (%)	PCE (%)
Cu/Mo	4.6	0.87	23.81	73.14	15.16
Ag	4.7	0.88	26.22	70.81	16.36
Fe	4.8	0.94	29.55	74.73	20.78
Cu-doped C	5.0	1.11	29.74	81.95	27.09
Au	5.1	1.17	29.74	80.42	28.08
W	5.2	1.18	29.74	80.16	28.17
Ni	5.5	1.18	29.74	80.15	28.17
Pd	5.6	1.18	29.74	80.15	28.17
Pt	5.7	1.18	29.74	80.15	28.17

addition, the influence of metal contacts with different work functions is studied in Section 3.4. Then, the effect of Ti alloying for the device with the highest PCE is briefly investigated in Section 3.5. Finally, devices with the highest PCE are selected from the simulations above, and their performances are investigated by varying series resistance (*R*_s), shunt resistance (*R*_{sh}), and working temperature from 1 to 10 Ω cm², 10 to 10⁷ Ω cm², and 300 to 400 K, respectively (Section 3.6). Subsequently, the material properties are elucidated using *J*–*V*, *C*–*V*, QE, electric field distributions, generation profiles, and recombination profiles from SCAPS-1D.

3. RESULTS AND DISCUSSION

3.1. Initial Device Performance. To acquire a suitable device configuration for enhanced performance of chalcogenide perovskites, we designed a base device structure (FTO/SnO₂/BaZrS₃/Cu₂S/Au) as illustrated in Figure 1a. The simulations were performed according to the parameters listed in Table 1, and the resulting *J*–*V* characteristics of the initial device and its respective PV parameters are provided in Figure 1b. Afterward, ETL, absorber, and HTL properties were optimized to enhance performance by varying their thickness,

carrier concentration, and defect density. The results of the simulations are shown in Section 3.2.

3.2. Optimization of ETL, Absorber, and HTL Parameters. To begin with, SnO₂ ETL was optimized by varying the parameters such as thickness, carrier concentration, and defect density. However, no significant changes in the PV parameters were observed with the ETL optimization, as shown in Figure S1. Interestingly, significant improvements in the device performance have been achieved by optimizing the absorber and HTL, which are comprehensively discussed in the following sections.

3.2.1. Impact of Absorbers Thickness, Carrier Concentration, and Defect Density. In this study, we varied the absorber thickness from 100 to 2000 nm. Figure 2a demonstrates that the *V*_{oc} reaches an optimum value of 1.37 V at 1000 nm and remains insignificant with an increase in thickness beyond 1000 nm. In contrast, the *J*_{sc} surges from 13.90 to 21.95 mA/cm² as the thickness increases from 100 to 2000 nm. This increase in *J*_{sc} is attributed to the enhanced spectral response at longer wavelengths.⁸³ Conversely, the *V*_{oc} saturates as the absorber becomes thick enough to absorb almost all incident light. This saturation could be linked to nonradiative losses associated with point defects, carrier lifetime, and interface recombination.⁸⁴ Examining Figure 2b, we observe that the FF increases from 48.64 to 79.12% as the thickness increases from 100 to 1000 nm and then diminishes. Conversely, the PCE experiences a substantial increase from 7.96 to 24.43% as the thickness increases from 100 to 2000 nm. Notably, the PCE increases by three times when the thickness extends from 100 to 1000 nm, while it improves by 0.94 times when the thickness is doubled from 1000 to 2000 nm. FF is the ratio of the maximum power output (*P*_{max}) to the product of *J*_{sc} and *V*_{oc} ($FF = \frac{P_{max}}{V_{oc} \times J_{sc}}$), while PCE is the ratio of

*P*_{max} to incident power of light i.e., $I_{in} \left(PCE = \frac{P_{max}}{I_{in}} \right)$.⁸⁴ The increased *J*_{sc} and *V*_{oc} at an optimum thickness result in higher FF. However, charge carrier depletion accelerates at an absorber thickness beyond 1000 nm, and the series resistance increases, leading to a subtle decrease in the fill factor.⁸⁵ Furthermore, the PCE of the device is influenced by both light absorption and carrier transport. When the absorber is thin, it absorbs a small portion of light and then transmits the unreflected remaining incident light, resulting in major absorption in the HTL. Subsequently, charge carriers accumulate near the back contact, enhancing recombination in the device. When the thickness increases, more light is absorbed in the absorber layer, reducing the buildup of charge carriers in the back contact.⁸³ This behavior is documented in Figure 2c, illustrating the charge carrier generation rate at two distinct thicknesses, 100 and 1000 nm. At 100 nm, the generation rate is higher in the HTL region than in the absorber region, indicating a large accumulation of charge carriers, while at 1000 nm, it is more prominent in the absorber region, revealing increased photon absorption in the absorber, resulting in enhanced device performance.⁸⁶ Additionally, QE measurements in Figure 2d show that the integral area of QE absorption increases from 27.2 to 62.9% when the thickness increases from 100 to 1000 nm, whereas it improves by only 1% with further increments to 2000 nm. Considering the device's generation rate, QE measurements, and manufacturing cost, 1000 nm is the optimum thickness.

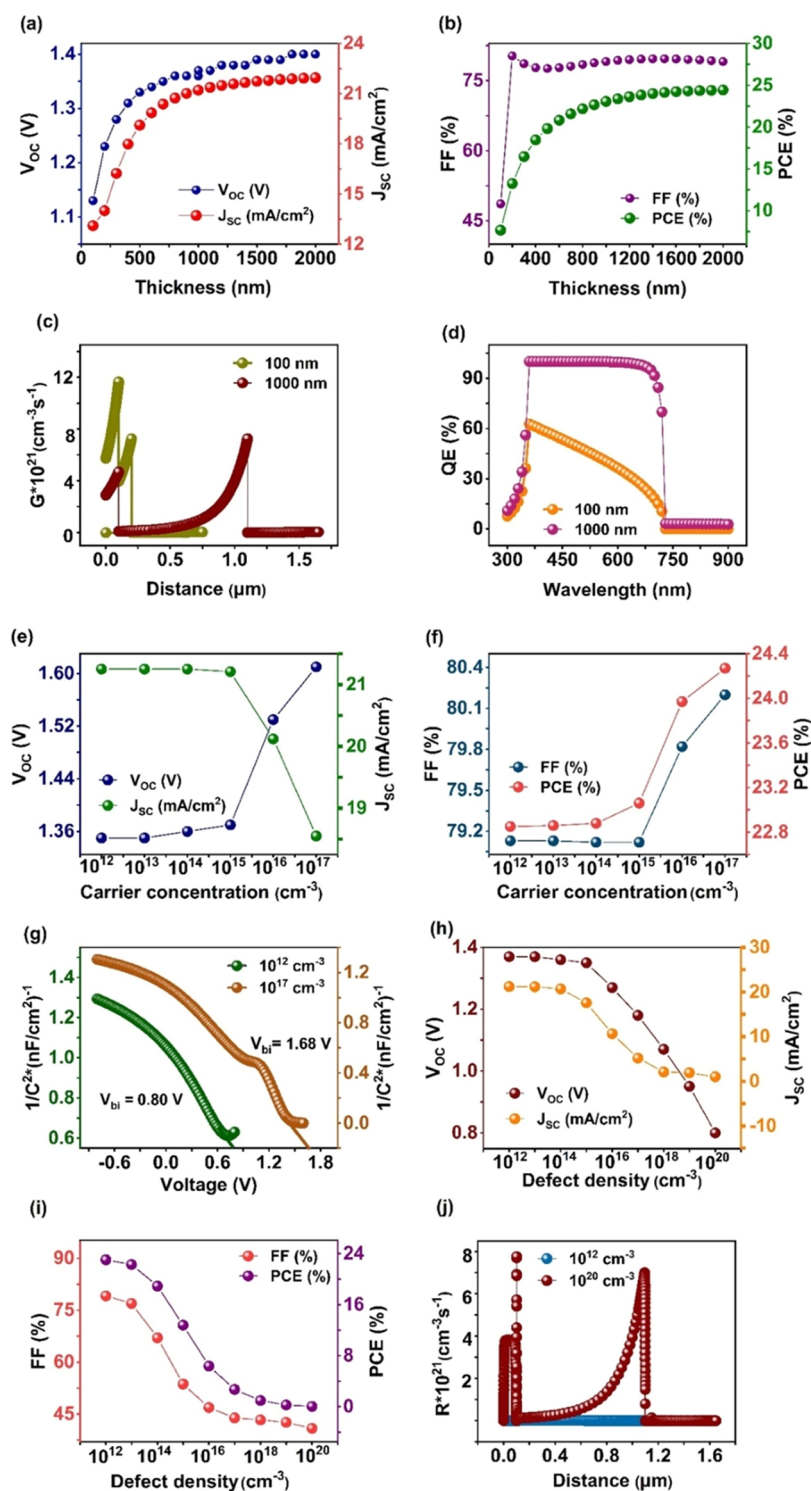


Figure 2. Changes in (a) V_{oc} , J_{sc} , (b) FF, PCE, (c) generation rate, and (d) QE as a function of absorber thickness. Changes in (e) V_{oc} , J_{sc} , (f) FF, PCE, and (g) Mott–Schottky as a function of the absorber carrier concentration. Changes in (h) V_{oc} , J_{sc} , (i) FF, PCE, and (j) recombination rate as a function of absorber defect density.

Higher carrier concentration can lead to Auger recombination and hinder hole transportation from the absorber to the HTL due to increased recombination rate and impurity scattering in the absorber.⁸⁷ To investigate this, we conducted simulations with carrier concentrations ranging from 10^{12} to 10^{17} cm^{-3} , as shown in Figure 2e,f. It can be noted that J_{sc} decreases with increasing carrier concentration, which can be attributed to the reduction in the diffusion length of minority

carriers and the depletion width.⁶ Conversely, V_{oc} and FF remain relatively stable from 10^{12} to 10^{14} cm^{-3} and increase beyond 10^{14} cm^{-3} . The increase in V_{oc} originates from the elevating built-in potential (V_{bi}) at the interfaces for higher carrier concentrations, which is evident in Figure 2g, where V_{bi} increases from 0.80 to 1.68 V when the carrier concentration is varied from 10^{12} to 10^{17} cm^{-3} . This subsequently improves the separation and collection of charge carriers at the respective

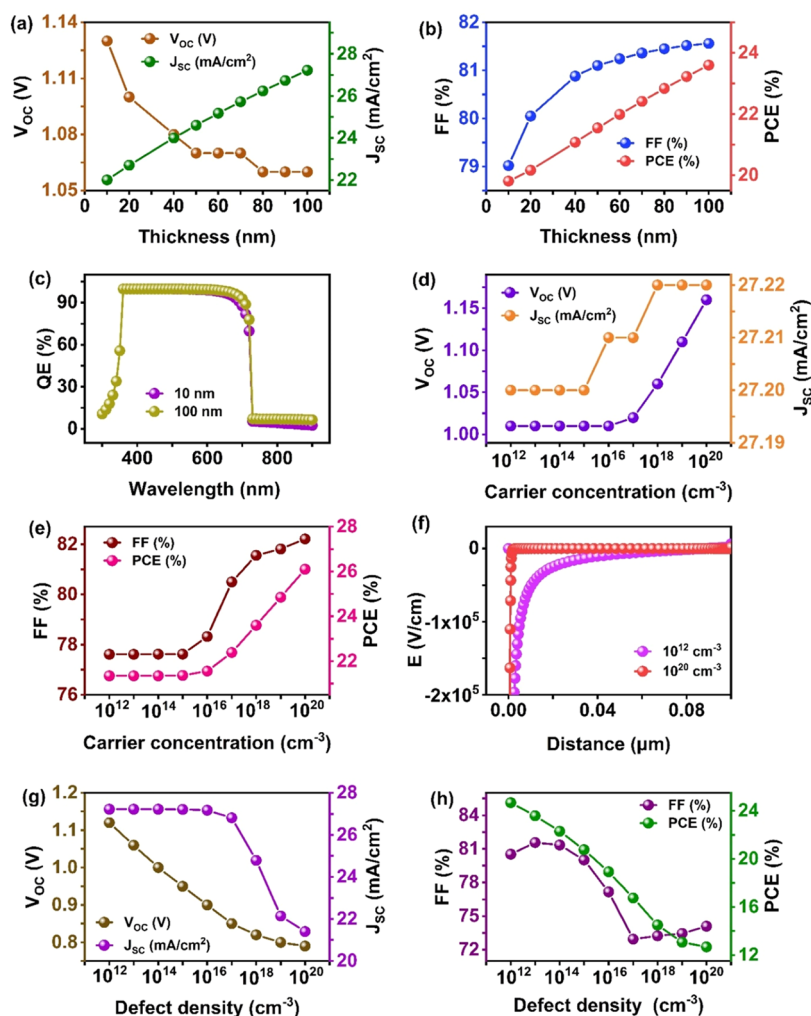


Figure 3. Changes in (a) V_{oc} , J_{sc} , (b) FF, PCE, and (c) QE as a function of HTL thickness. Changes in (d) V_{oc} , J_{sc} , (e) FF, PCE, and (f) electric field (E) along the HTL region as a function of HTL carrier concentration. Changes in (g) V_{oc} , J_{sc} , (h) FF, and PCE as a function of HTL defect density.

contacts without recombination. However, the increase in FF is linked to the reduction in series resistance in the absorber layer.⁸⁸ Overall, when the carrier concentration is increased from 10¹² to 10¹⁷ cm⁻³, PCE is enhanced from 22.85 to 24.27% due to the increase in V_{oc} and FF, while the decrease in J_{sc} does not affect the device performance. However, Meng et al. reported that only a weakly p-type BaZrS₃ film is possible under stoichiometric (S-rich/Zr-poor) conditions. Based on this understanding, we performed further simulations by selecting a carrier concentration of 10¹⁵ cm⁻³ instead of 10¹⁷ cm⁻³, even though the latter achieved a higher efficiency.³⁷

Defects play a significant role in regulating interfacial recombination, carrier lifetime, and material doping levels. They can arise from uncoordinated atoms, nonstoichiometry, etc., and are predominantly found at the interface, surface, or grain boundaries. Bulk defects, such as interstitial and vacancy defects, and Schottky and Frenkel defects, also adversely affect the absorber's properties.³⁷ Therefore, the influence of defect density is studied and reported in Figure 2h,i. As the defect density increases, a decrease in all of the PV parameters is observed. This can be attributed to the increased recombination rate (Figure 2g) at higher defect densities.⁸⁹ Thus, a defect density of 10¹² cm⁻³ is selected as an optimum value for the BaZrS₃ absorber. Generally, BaZrS₃ synthesized under S-rich/

Zr-poor conditions is identified to be defect-tolerant owing to its high formation energy, which surpasses deep-level defects, revealing the possibility of achieving lower defect density experimentally.³⁸

3.2.2. Impact of HTL Thickness, Carrier Concentration, and Defect Density. The thickness of the HTL is varied from 10 to 100 nm (Figure 3a,b), where a slight decrease in V_{oc} from 1.13 to 1.06 V is observed, indicating a surging probability of recombination with HTL thickness.⁸⁵ In contrast, J_{sc} improves from 22.01 to 27.22 mA/cm² with increasing HTL thickness due to the enhanced light absorption in the device.⁹⁰ This can also be witnessed in Figure 3c, where the absorption increases from 54 to 61% when the HTL thickness is extended from 10 to 100 nm. In addition, FF improves marginally from 79.02 to 81.56%, resulting from the enriched charge transportation from the absorber.⁹¹ As a result, PCE increases from 19.81 to 23.60%, primarily driven by increased J_{sc} and FF. Generally, the HTL should be thicker than the ETL to ensure an equal number of charge carriers reach the terminals simultaneously, minimizing the likelihood of recombination. Additionally, a thicker HTL creates room for more photons to be absorbed.⁶ Based on these considerations, an optimal thickness of 100 nm is selected for further optimization.

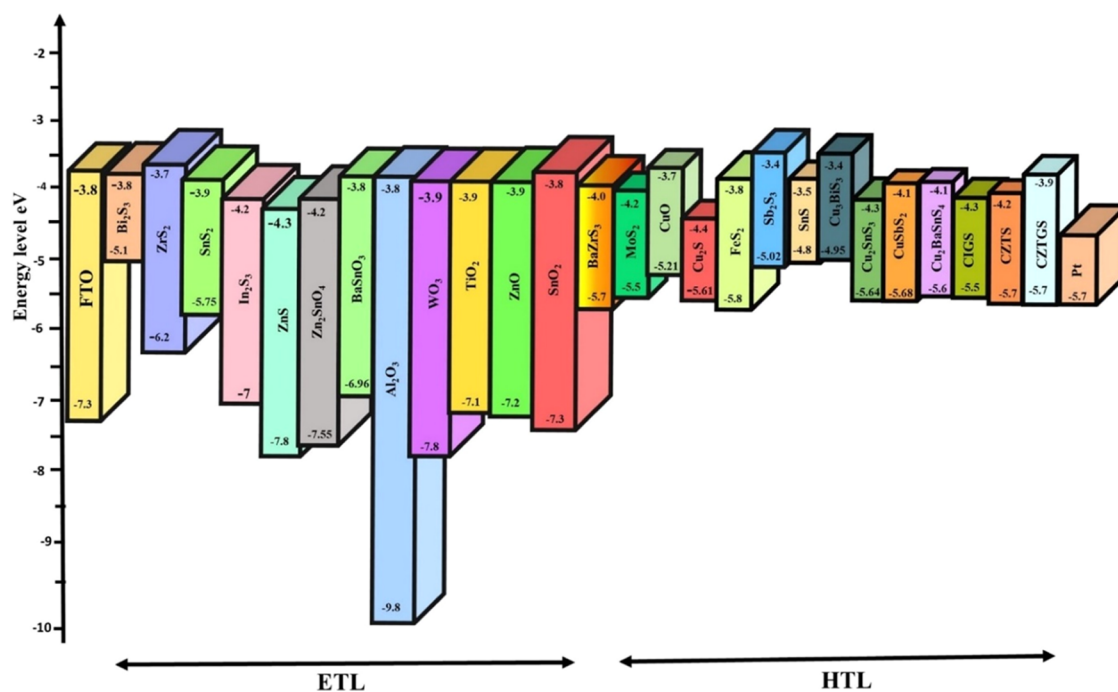


Figure 4. Schematic representation of energy-level diagram for different ETLs, HTLs, and BaZrS₃ chalcogenide perovskite absorbers.

We varied the carrier concentration from 10^{12} to 10^{20} cm^{-3} , as displayed in Figure 3d,e. It can be observed that all of the PV parameters exhibit insignificant changes until a concentration of 10^{15} cm^{-3} . This indicates that the carrier concentration of the HTL does not influence the PV parameters when it is lower than that of the absorber. However, when the carrier concentration exceeds 10^{15} cm^{-3} , the variation in J_{sc} remains insignificant, while V_{oc} demonstrates an increase from 1.01 to 1.16 V, which together with the improvement in the FF from 77.61 to 82.21%, enhances the PCE from 21.35 to 26.10%. This elevation in PCE is attributed to the upward shift in energy bands that occurs with an increase in the carrier concentration. Consequently, a strong built-in electrical field is formed at the interface, as displayed in Figure 3f. This intense electric field promotes the transportation of holes from BaZrS₃ to the back contact through Cu₂S by raising the charge transport velocity and conductivity⁹² while restricting the flow of minority carriers, thereby reducing the carrier recombination rate. Overall, it is evident that the carrier concentration of the HTL must be higher than that of the absorber to achieve high device performance. As a result, a carrier concentration of 10^{20} cm^{-3} is selected for further studies.

Defects create additional nonradiative recombination pathways, converting light into heat instead of electricity. In particular, the recombination centers trap the photogenerated carriers before they can reach the terminals of the device, thus reducing the carrier's lifetime.⁹³ Therefore, it is crucial to minimize defects to enhance the performance of devices. To analyze the influence of defect density, we varied the defect density of the HTL from 10^{12} to 10^{20} cm^{-3} , as displayed in Figure 3g,h. There was a noticeable reduction in the V_{oc} , J_{sc} , FF, and PCE from 1.19 to 0.91 V, 27.22 to 21.40 mA/cm^2 , 81.46 to 76.58%, and 26.46 to 15.02%, respectively. This significant decrease in the PV parameters can be attributed to decreased carrier diffusion length at higher defect densities, resulting in an increased recombination rate at the BaZrS₃/

Cu₂S interface.⁹⁴ Therefore, a HTL defect density of 10^{12} cm^{-3} is required for highly efficient chalcogenide perovskite devices.

3.3. Influence of Different ETL and HTL. We systematically examined 12 ETLs (Bi₂S₃,^{51,52} ZrS₂,^{53,54} SnS₂,⁵⁵ In₂S₃,⁵⁶ ZnS,⁵⁶ Zn₂SnO₄,⁵⁷ BaSnO₃,⁵⁸ Al₂O₃,^{59,60} WO₃,⁵⁹ TiO₂,⁶¹ ZnO,⁶¹ SnO₂,⁶¹) and 13 HTLs (MoS₂,⁶³ CuO,⁶⁴ Cu₂S,⁶⁵ FeS₂,⁶⁶ Sb₂S₃,⁶⁷ SnS,⁶⁸ Cu₃BiS₃,⁶⁹ Cu₂SnS₃,⁷⁰ CuSbS₂,⁷¹ Cu₂BaSnS₄,⁷² CuInGaS₂,⁷³ Cu₂ZnSnS₄,⁷⁴ Cu₂ZnSn_{1-x}Ge_xS₄⁷⁴) to identify suitable transport layers for emerging BaZrS₃ chalcogenide perovskite devices (Figure 4) and their simulation parameters are given in Table S1. As previously discussed, we initially optimized SnO₂ (ETL), BaZrS₃ (absorber), and Cu₂S (HTL) in our base device by varying the thickness, carrier concentration, and defect density. We altered the ETL and changed the abovementioned parameters in this optimized configuration. Then, while keeping the optimized ETL and absorber, we varied 13 HTLs and optimized their parameters to determine the most suitable device structure. We applied this approach to all of the remaining ETLs and HTLs, resulting in 782 devices (Table S1). Among them, 156 devices demonstrated the highest PCE for each ETL and HTL combination (Table S2). Interestingly, 139 devices showed a PCE > 20%, and 50 devices exhibited a PCE over 25%. Notably, 10 of these devices displayed an impressive PCE above 27%. To be specific, the devices that are represented as SC11, SC24, SC37, SC50, SC63, SC76, SC89, SC102, and SC128 in Table S2 demonstrated efficiencies of 27.34, 27.44, 27.44, 27.35, 27.43, 27.44, 27.35, 27.34, and 27.47%, respectively, and the highest PCE of 28.08% was accomplished for the champion device SC141 with structure ZrS₂/BaZrS₃/SnS. Figure 5 displays the QE of the aforementioned 10 devices with PCE greater than 27% in the wavelength range of 300–900 nm. An average QE > 70% was obtained for all device structures, wherein the highest QE of 76.23% was achieved for the champion SC141, which reveals that the light absorption in this device is considerably increased. The generated charge carriers are efficiently

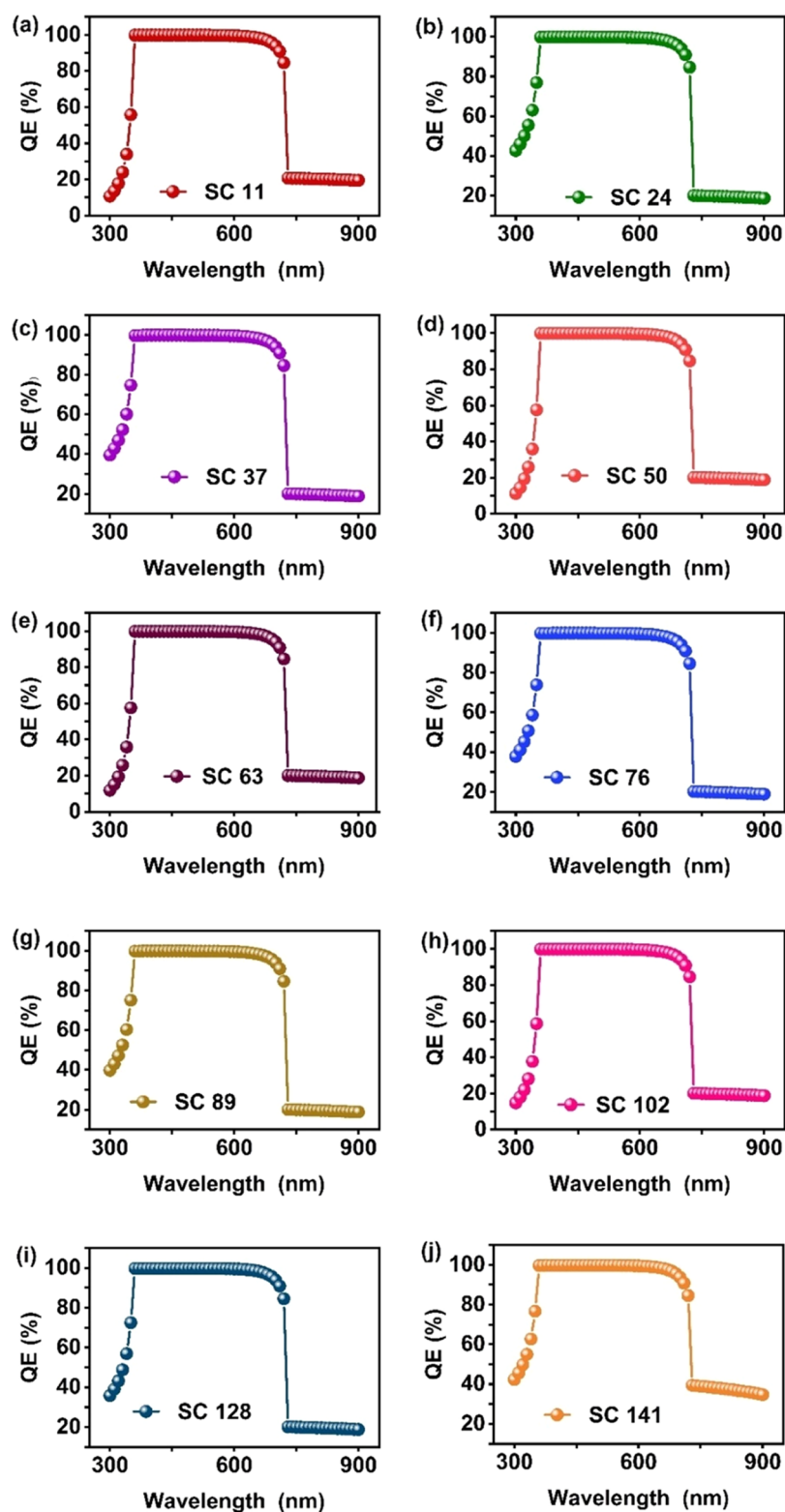


Figure 5. QE measurements of 10 devices obtained a PCE of >27%. (a) SC11, (b) SC24, (c) SC37, (d) SC50, (e) SC63, (f) SC76, (g) SC89, (h) SC102, (i) SC128, and (j) SC141.

separated and collected at the contacts with less recombination due to the proper band alignment at the $\text{ZrS}_2/\text{BaZrS}_3$ and $\text{BaZrS}_3/\text{SnS}$ interface, leading to its superior device performance.

The critical factor behind the device's overall performance is the band alignment between the absorber, ETL, and HTL.

This alignment guarantees the effective separation and transportation of charge carriers. Conversely, any disparity in energy band positioning could lead to elevated carrier recombination and increased interface resistance. To understand the obtained PCE as a function of their energy band alignment, we selected three devices among 156 devices,

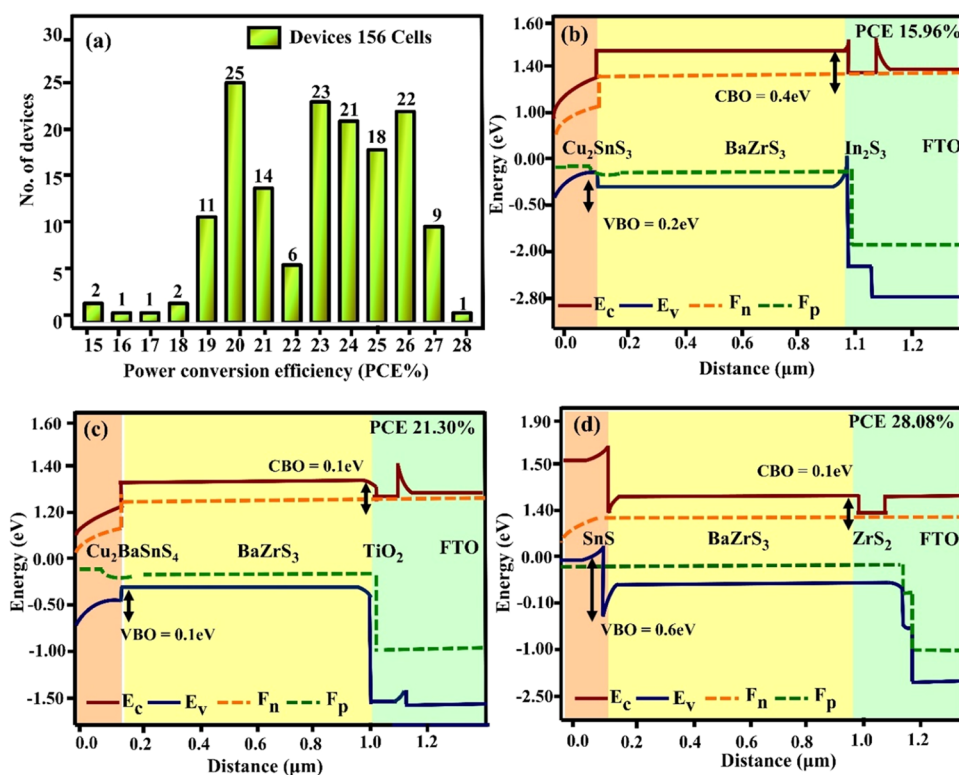


Figure 6. (a) Histogram of PCE for 156 devices detailed in Table S2. Energy band diagram for device structures, (b) In₂S₃/BaZrS₃/Cu₂SnS₃, (c) TiO₂/BaZrS₃/Cu₂BaSnS₄, and (d) ZrS₂/BaZrS₃/SnS.

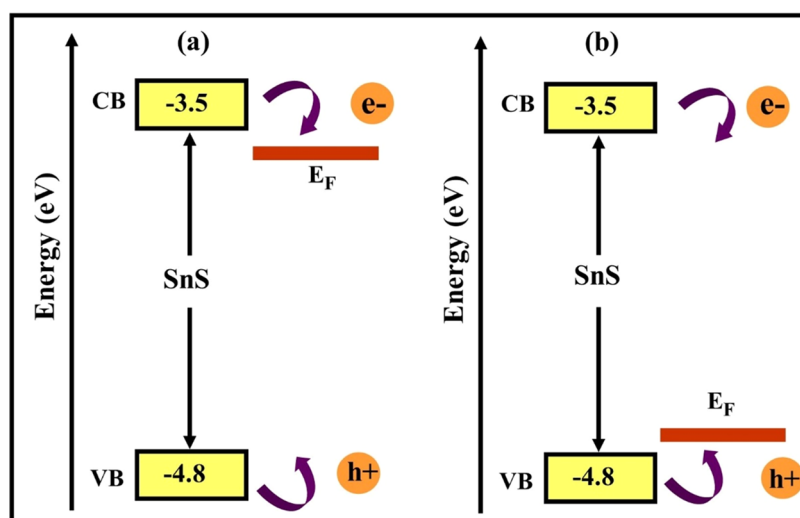


Figure 7. Influence of (a) lowest and (b) highest metal work functions in the device performance.

demonstrating low (In₂S₃/BaZrS₃/Cu₂SnS₃, 15.96%), intermediate (TiO₂/BaZrS₃/Cu₂BaSnS₄, 21.30%), and high (ZrS₂/BaZrS₃/SnS, 28.08%) PCEs, and their corresponding energy band diagrams were extracted from SCAPS-1D (Figure 6b–d) to perform a comparative analysis. It can be seen in Figure 6b that a spike-like barrier is observed at the BaZrS₃/In₂S₃ and In₂S₃/FTO interface, respectively. This leads to the accumulation of electrons at both interfaces, which impedes flow to the front contact, resulting in high interface recombination.⁹⁵ Considering the Cu₂SnS₃/BaZrS₃ interface, a VBO of 0.2 eV indicates a smaller barrier for holes. However, a cliff at the CBO reveals that most holes will be collected in the HTL instead of blocking the electrons, leading to high recombina-

tion at the interface.⁹⁶ A similar kind of alignment is observed for TiO₂/BaZrS₃/Cu₂BaSnS₄ (Figure 6c) with a difference that the CBO is comparatively low at the TiO₂/BaZrS₃ interface, reducing the accumulation of electrons and leading to improved PCE. Interestingly, for ZrS₂/BaZrS₃/SnS devices (Figure 6d), we can see that the cliff-like barrier at ZrS₂/BaZrS₃ is reduced to 0.1 eV. Also, the barrier height at the ZrS₂/FTO interface is minute, which minimizes the electron accumulation in the ETL and facilitates the transportation of electrons to the front contact. In addition, CBO at the BaZrS₃/SnS interface is high (0.3 eV), which blocks the flow of electrons to SnS, preventing the recombination at the interface. However, we can see that VBO at the BaZrS₃/SnS interface is

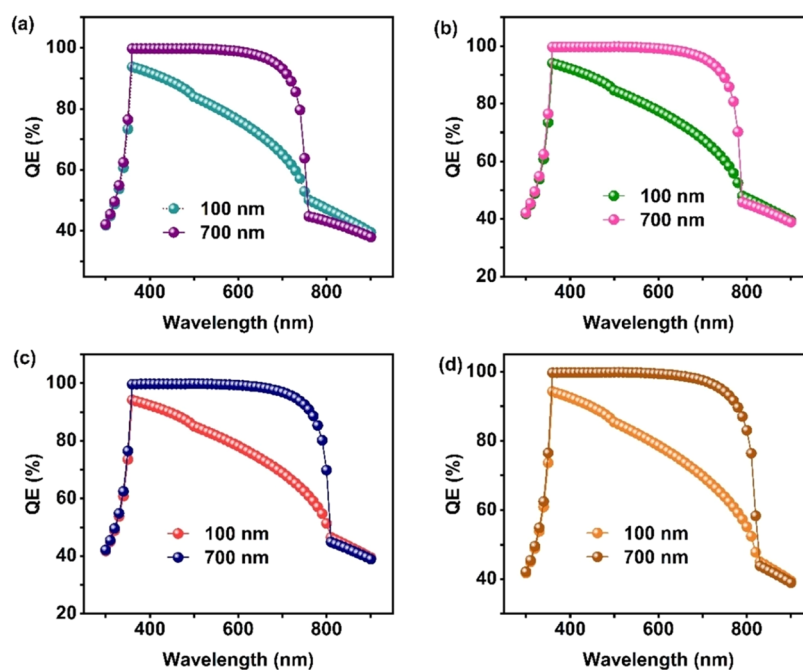


Figure 8. Changes in the QE % for devices (a) T1, (b) T2, (c) T3, and (d) T4 as a function of absorber thickness.

0.6 eV, which is comparatively larger than the VBO of Cu_2SnS_3 (0.2 eV) and $\text{Cu}_2\text{BaSnS}_4$ (0.1 eV)-based devices used for the comparison. Nevertheless, SnS portrays degenerate behavior, i.e., the quasi-hole Fermi level is within the valence band. This implies that the conductivity is substantial at the $\text{BaZrS}_3/\text{SnS}$ interface, which enhances the flow of holes from the absorber to HTL, irrespective of the large barrier.⁹⁷ Consequently, it enhances the collection of holes at the back contact. Thus, the high conductivity of SnS, in combination with less barrier for electrons at the ETL/absorber interface and high barrier for electrons at the HTL/absorber interface, resulted in the highest PCE of the $\text{ZrS}_2/\text{BaZrS}_3/\text{SnS}$ device. Hence, achieving a suitable alignment enhances charge separation and transport, reduces recombination losses, and boosts device efficiency, which underscores the importance of understanding band alignment to craft high-performance devices.

3.4. Influence of Different Metal Contacts. To study the influence of metal contacts on the high-performing device $\text{ZrS}_2/\text{BaZrS}_3/\text{SnS}$ (PCE 28.08%), we varied different metal contacts, namely, Cu/Mo, Ag, Fe, Cu-doped C, Au, W, Ni, Pd, and Pt with work functions of 4.6, 4.7, 4.8, 5.0, 5.1, 5.2, 5.5, 5.6, and 5.7 eV, respectively. As displayed in Figure 7a,b, when the work function is low (4.6), the Fermi level of the metal contact approaches the conduction band of the HTL, leading to a significant barrier for hole transfer from the HTL to the metal contact. In addition, due to a low barrier (1.1 eV) for electrons, there is easy transfer between the conduction band of the HTL and the metal contact, leading to increased recombination in devices. Interestingly, a higher metal work function induces an inverse bending of the energy bands, facilitating the transfer of photogenerated holes to the metal contacts while creating a Schottky barrier (2.2 eV) for electron transfer.⁹⁸ This behavior is observed in Pt contacts, where the metal's Fermi level moves toward the valence band of the HTL, resulting in effortless hole transportation and improved device performance. However, the PCE of devices with Ni, Pd, and Pt metal contacts remains constant (Table 2). This phenomenon is attributed to the saturation of the V_{bi} when the

metal work function increased beyond 5.2 eV, primarily caused by increased ohmic resistance at the HTL/metal contact interface.¹⁰⁰ Consequently, we achieved the highest PCE of 28.17% with the $\text{ZrS}_2/\text{BaZrS}_3/\text{SnS}/\text{Pt}$ device structure.

3.5. Investigating the Influence of Ti Alloying in the BaZrS_3 Absorber. Alloying is a widely employed technique to attain the desired optoelectronic properties that enhance the device's overall performance. Thus, alloying BaZrS_3 with a suitable metal can further enhance its optical properties. Notably, the band gap of BaZrS_3 (1.7 eV) is slightly larger than the optimal band gap for single-junction devices, as governed by the Shockley–Queisser limit.^{38,99} To reduce BaZrS_3 's band gap through alloying, Ti and Se are ideal choices due to their favorable energy states, atomic size, and electronegativity. In a first-principles study, Meng et al. demonstrated that Ti alloying lowers the conduction band edge, making Ti suitable for facilitating the n-type character in BaZrS_3 , while Se alloying raises the valence band edge, making it ideal for lowering the band gap and enabling p-type doping by shallowing the acceptors.³⁸ However, Se alloying exhibits a bowing effect, familiar in anion alloying, and requires approximately 1 atom % of Se to achieve the same band gap reduction, which is significantly higher than the 0.1 atom % estimated for Ti.³⁸ Considering these factors, we focused on Ti alloying for our study. The alloying process was performed on the best device structure, incorporating ZrS_2 as the ETL, SnS as the HTL, and $\text{Ba}(\text{Zr}_{1-x}\text{Ti}_x)\text{S}_3$ as an absorber with x values ranging from 0.01 to 0.04. This small concentration of alloying effectively reduced the band gap from 1.71 to 1.51 eV and resulted in a performance boost.⁷⁵ Therefore, we investigated the influence of alloying with four different concentrations: $\text{Ba}(\text{Zr}_{0.99}\text{Ti}_{0.01})\text{S}_3$ (Device T1), $\text{Ba}(\text{Zr}_{0.98}\text{Ti}_{0.02})\text{S}_3$ (Device T2), $\text{Ba}(\text{Zr}_{0.97}\text{Ti}_{0.03})\text{S}_3$ (Device T3), and $\text{Ba}(\text{Zr}_{0.96}\text{Ti}_{0.04})\text{S}_3$ (Device T4) on the PCE as shown in the following subsections.

3.5.1. Impact of Ti Alloying in Absorbers Thickness, Carrier Concentration, and Defect Density. The thickness of the absorber is varied from 100 to 1000 nm to study its influence on the PV parameters for devices T1, T2, T3, and T4

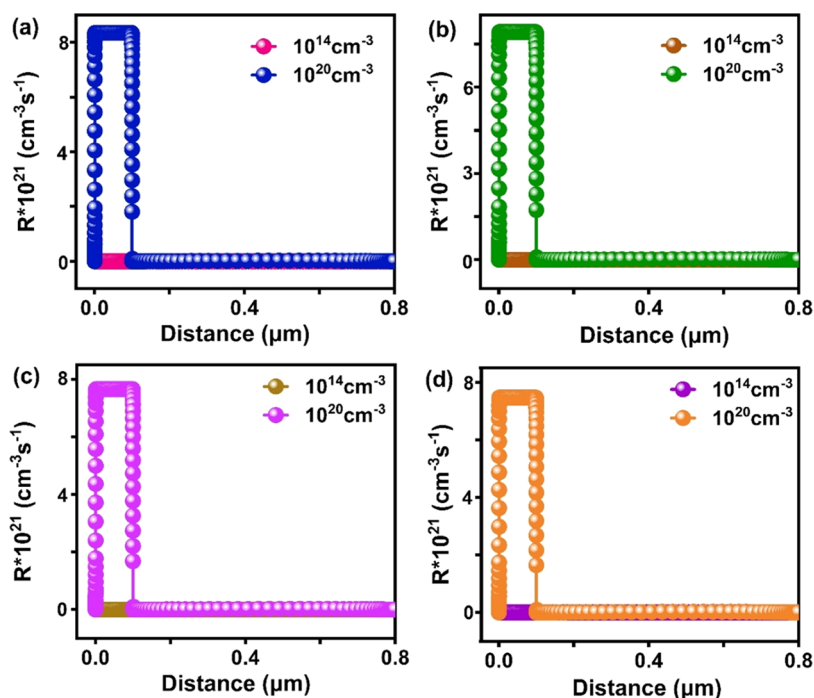


Figure 9. Changes in the recombination rate at the HTL/absorber region in (a) T1, (b) T2, (c) T3, and (d) T4 as a function of the absorber carrier concentration.

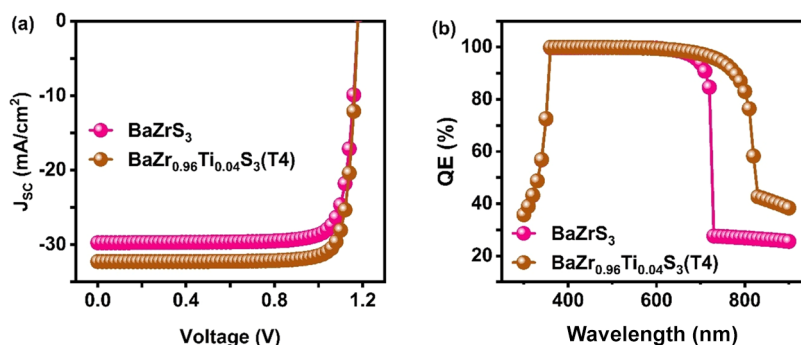


Figure 10. Changes in the (a) J - V curve and (b) QE measurements as a function of band gap in BaZrS_3 and $\text{Ba}(\text{Zr,Ti})\text{S}_3$ devices.

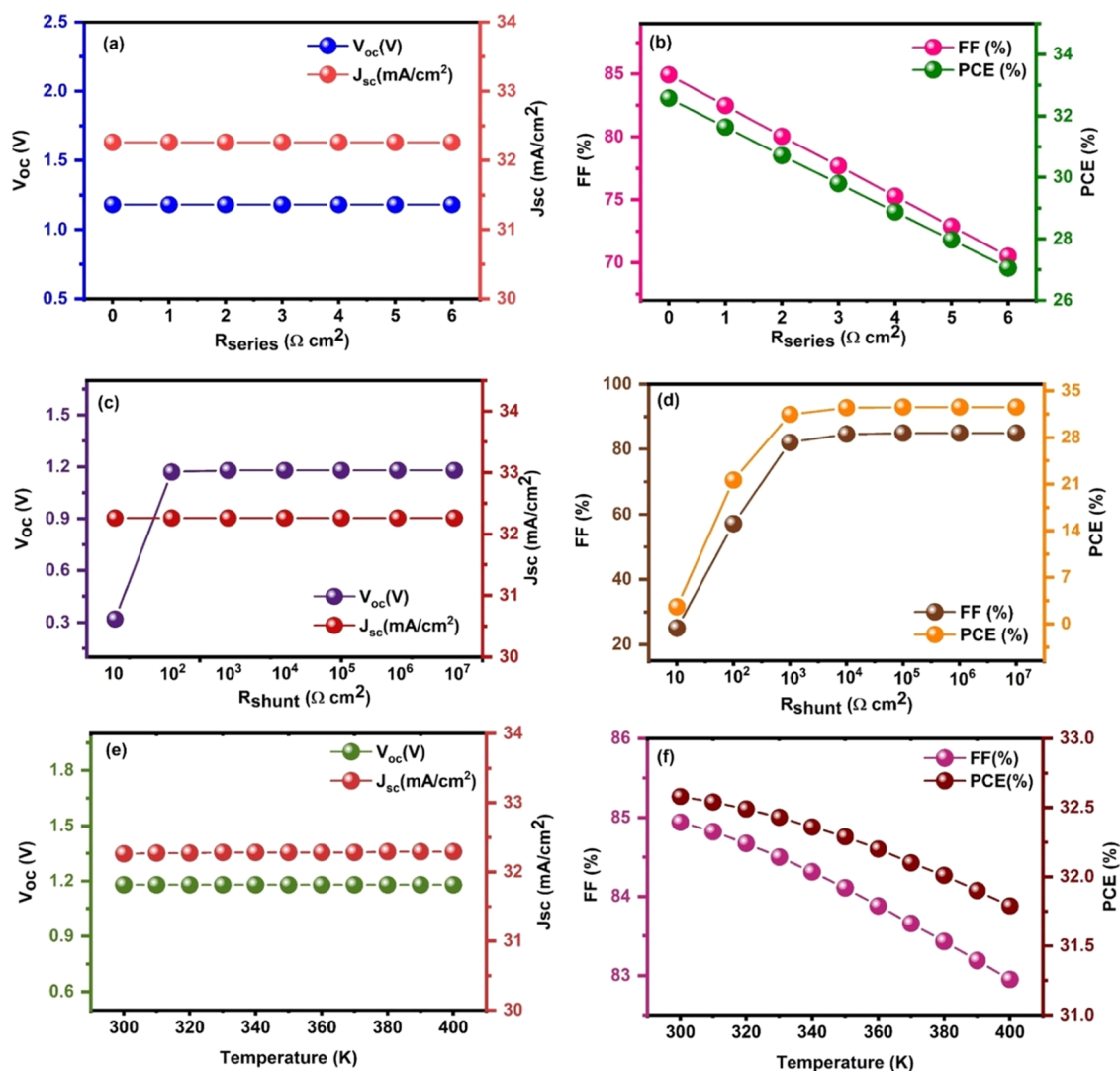
(Figure S2). A modest increase in V_{oc} is noticed due to improved quasi-Fermi-level splitting, while a significant increase in J_{sc} values results from increased absorption.¹⁰⁰ Conversely, a subtle reduction in FF is linked to increased internal resistance associated with thickness. Notably, the PCE demonstrates an initial increase with thickness up to 700 nm, followed by a marginal decline. This dip aligns with increased recombination rates at higher thicknesses due to the extended travel path for photogenerated charge carriers.⁹⁴ Interestingly, for absorber thickness ranging from 100 to 700 nm, devices T1, T2, T3, and T4 exhibit escalated PCEs from 26.64 to 30.20%, 27.20 to 31.43%, 27.53 to 32.09%, and 27.59 to 32.57%, respectively. This trend is further confirmed by QE measurements (Figure 8a–d). The QE drops for devices with less thickness, while a consistent spectral response occurs from 348 to 763 nm, 358 to 790 nm, 355 to 808 nm, and 350 to 840 nm, accompanied by an absorption increase of 79.02, 82.14, 83.85, and 85.24% for devices T1, T2, T3, and T4, respectively. Notably, a reduced band gap expands the absorption range into the NIR range (750–840 nm), fostering increased absorption and boosting performance.

Analyzing the impact of carrier concentration (10^{12} to 10^{20} cm^{-3}) on devices T1, T2, T3, and T4 (Figure S3) unveils a clear trend. It can be observed that J_{sc} and PCE remain stable until 10^{14} cm^{-3} , beyond which a slight decrease occurs. The root cause of this behavior is the escalated recombination rate observed at higher carrier concentrations (Figure 9a–d). Within 10^{12} to 10^{14} cm^{-3} , recombination in the HTL region remains the same, attributing to the unaltered device performance. However, beyond 10^{14} cm^{-3} , recombination in the HTL region increases significantly, resulting in a rapid decrease in J_{sc} and PCE. While a slight increase in V_{oc} and FF with higher carrier concentration may occur due to elevated electric fields at the interfaces, this can also intensify the possibility of recombination.⁸⁸ Thus, increasing the carrier concentration of the absorber beyond an optimum value led to a dramatic increase in HTL recombination, adversely affecting the device performance. Therefore, an optimal carrier concentration of 10^{14} cm^{-3} is chosen for further simulations.

Likewise, the influence of defect density for the devices T1, T2, T3, and T4 is analyzed by varying it from 10^{12} to 10^{20} cm^{-3} . A steep increase in the V_{oc} is observed for unknown

Table 3. Lattice Mismatch of BaZrS₃ and Ba(Zr_{0.96}Ti_{0.04})S₃ with ETL and HTL

layers	lattice parameters (Å)			lattice mismatch (%)	
	<i>a</i>	<i>b</i>	<i>c</i>	ETL/absorber	absorber/HTL
BaZrS ₃	7.06	9.98	7.02	19.17	55.09
Ba(Zr _{0.96} Ti _{0.04})S ₃	7.05	9.90	7.02	19.08	45.60
ZrS ₂ (ETL)	3.65		5.80		
SnS (HTL)	3.64	11.21	3.99		

Figure 11. Changes in the PV parameters as a function of (a, b) R_s , (c, d) R_{sh} , and (e, f) working temperature.

reasons, while J_{sc} , FF, and PCE decrease (Figure S4) with defect density. This is attributed to higher defects acting as traps for photogenerated charge carriers, hindering their separation as they have lower diffusion lengths and carrier lifetime.⁹⁴ As a result, a high PCE is observed at 10^{12} cm⁻³, chosen as the optimal defect density for further studies.

3.5.2. Output Performance of BaZrS₃ and Ba(Zr_{0.96}Ti_{0.04})S₃ Devices. The J - V characteristics of devices utilizing BaZrS₃ and Ba(Zr_{0.96}Ti_{0.04})S₃ (T4) are shown in Figure 10a. Strikingly, the Ba(Zr,Ti)S₃ absorber yields a higher PCE of 32.58% compared to that of BaZrS₃ (PCE of 28.17%). This enhancement is primarily attributed to the improved J_{sc} arising from more light absorption as it has a lower band gap of 1.51 eV in Ba(Zr,Ti)S₃ than 1.7 eV in BaZrS₃. Additionally, optimal

band alignment contributes to reduced recombination at the interface. Moreover, the low band gap of Ba(Zr,Ti)S₃ enables it to absorb a large fraction of solar spectrum incident upon it, resulting in a high PCE.

The obtained QE plots for BaZrS₃ and Ba(Zr,Ti)S₃ are displayed in Figure 10b. It can be noticed that the absorption edge is at 729 nm for BaZrS₃ and 858 nm for Ba(Zr,Ti)S₃. This is due to alloying, which shifts the absorption to the NIR region as it has a lower band gap. This increased absorption from 76 to 85% in the NIR region contributes to the enhancement in the PCE in association with an increase in J_{sc} significantly impacting the device performance.

Furthermore, the improvement in PCE can be justified by calculating the lattice mismatch. In general, the lattice

mismatch between layers and surface roughness causes interfacial defects, which act as recombination centers and negatively impact the performance of the devices. Additionally, it affects the symmetry at the ETL/absorber and absorber/HTL interfaces, causing dislocations, point defects, and lattice inhomogeneities.⁴⁷ Therefore, we assessed the lattice mismatch (δ) between the transport layers and the absorber for device structures that achieved the best PCE of 32.58% (FTO/ZrS₂/Ba(Zr_{0.96},Ti_{0.04})S₃/SnS/Pt) and 28.17% (FTO/ZrS₂/BaZrS₃/SnS/Pt) using the formula

$$\delta = 2|a_s - a_e|/|a_s + a_e| \quad (4)$$

Here, “ a_s ” represents the lattice constant of the substrate, while “ a_e ” stands for the lattice constant of the epitaxial layer.⁹⁴

Table 3 displays the lattice constants^{47,101,102} and compares the δ values for BaZrS₃ and Ba(Zr_{0.96}Ti_{0.04})S₃ absorbers concerning the ETL and HTL layers. The ZrS₂/BaZrS₃ and BaZrS₃/SnS interface exhibits δ values of 19.17 and 55.09%, respectively. On the other hand, slightly lesser δ values of 19.08 and 45.60% are observed for the ZrS₂/Ba(Zr_{0.96},Ti_{0.04})S₃ and Ba(Zr_{0.96},Ti_{0.04})S₃/SnS interface, respectively. It is evident that the reduction in mismatch is closely linked to the concentration of Ti alloying at the Zr site.⁴⁷ This reduces the carrier recombination rate and minimizes the occurrence of dislocation or defects at the Ba(Zr_{0.96}Ti_{0.04})S₃ interface, leading to enhanced performance.

3.6. Influence of R_s , R_{sh} , and Working Temperature. Parasitic resistances, such as R_s and R_{sh} , play a significant role in the PV performance of the device. These resistances dictate the characteristics of J – V curves and reflect the considerable loss mechanisms within the device. In general, devices should exhibit low R_s and high R_{sh} values. However, in practical applications, R_s depends on the contacts between charge transfer layers (ETL and HTL) and the metal contact layer, which affects charge transfer. Likewise, R_{sh} may be reduced due to factors like morphologies or unavoidable leakage currents.⁴⁷ Hence, this section explores the influence of varying R_s and R_{sh} of the final device T4 (FTO/ZrS₂/Ba(Zr_{0.96},Ti_{0.04})S₃/SnS/Pt).

Initially, the R_s of the device is varied from 1 to 10 Ω cm², as displayed in Figure 11a,b. It can be noticed that V_{oc} and J_{sc} remain unaltered across the entire range. However, a decrease in FF is evident, dropping from 84.94 to 70.52%, with an increase in R_s attributed to the substantial power loss within the device. Since power loss is directly proportional to R_s , increasing R_s leads to higher power loss, impacting FF. Consequently, the PCE of the device reduced from 32.58 to 27.05%. This underscores the importance of maintaining a low R_s of 1 Ω cm² for efficient device functioning. Thereafter, we varied the R_{sh} from 10 to 10⁷ Ω cm² to study its influence on the performance of the devices (Figure 11c,d). The findings reveal a slight increase in V_{oc} up to 10³ Ω cm²; after that, it remains unchanged. Likewise, J_{sc} remains constant. On the other hand, when the R_{sh} is increased from 10 to 10⁷ Ω cm², an increase in FF and PCE from 25 to 84.94% and 2.60 to 32.58% is observed. Therefore, with higher values of R_{sh} , the device shows improved performance.^{37,47}

The impact of temperature has been investigated by varying it from 300 to 400 K. Figure 11e,f illustrates the changes in the PV parameters as a function of temperature. The J_{sc} and V_{oc} remain unaltered throughout the entire range, whereas the FF and PCE experience a slight decrease from 84.94 to 82.95% and 32.58 to 31.79%, respectively. This can be attributed to the

increased R_s and charge carrier recombination within the layers at elevated temperatures. Yet, it is noteworthy that the PCE dropped by just 0.8%, underscoring the stability of Ba(Zr,Ti)S₃ compared with lead halide perovskites. Therefore, these findings highlight the potential of Ba(Zr,Ti)S₃ as a stable PV device.^{37,48}

4. COMPARISON OF SCAPS-1D RESULTS WITH BAZRS₃ AND BA(ZR,TI)S₃ CHALCOGENIDE PEROVSKITE DEVICES IN THE LITERATURE

Table 4 summarizes theoretical works on chalcogenide perovskite absorbers (BaZrS₃, BaZrSe₃, Ba(Zr,Ti)S₃) using

Table 4. Summary of BaZrS₃ and Ba(Zr,Ti)S₃ Chalcogenide Perovskite Devices Reported in the Literature

device structure	V_{oc} (V)	J_{sc} (mA/cm ²)	FF (%)	PCE (%)	ref
FTO/TiO ₂ /BaZrS ₃ /Spiro-OMeTAD/Au	1.21	16.54	86.26	17.29	89
FTO/TiO ₂ /BaZrS ₃ /Cu ₂ O/Au	1.16	12.24	87.13	12.42	47
FTO/TiO ₂ /BaZrS ₃ /CuSbS ₂ /W	1.00	22.57	73.7	17.13	106
FTO/TiO ₂ /BaZrS ₃ /Spiro-OMeTAD/Au	0.70	22.00	79.40	12.12	107
AZO/i-ZnO/CdS/BaZrS ₃ /a-Si	1.31	19.08	78.88	19.72	37
FTO/TiO ₂ /BaZrSe ₃ /Spiro-OMeTAD/Au	0.72	46.65	77.32	25.84	107
FTO/TiO ₂ /Ba(Zr _{0.87} Ti _{0.12})S ₃ /Cu ₂ O/back contact	1.09	26.57	85.78	24.86	108
AZO/i-ZnO/CdS/Ba(Zr _{0.95} Ti _{0.05})S ₃ /a-Si	1.26	27.06	88.47	30.06	37
FTO/ZrS ₂ /BaZrS ₃ /SnS/Pt	1.18	29.74	80.15	28.17	this work
FTO/ZrS ₂ /Ba(Zr _{0.96} Ti _{0.04})S ₃ /SnS/Pt	1.18	32.26	84.94	32.58	this work

SCAPS-1D. Notably, the highest PCE of 30% emerged from the (a-Si)/Ba(Zr_{0.95},Ti_{0.05})S₃/CdS/i-ZnO/AZO device. However, its inclusion of CdS has a buffer layer containing the toxic element Cd, which limits its commercialization due to environmental toxicity concerns.¹⁰³ Following closely, the (FTO/TiO₂/BaZrSe₃/Spiro-OMeTAD/Au) device achieved the second highest PCE of 25% by employing Spiro-OMeTAD. Although it is a prominently used HTL, its stability and high cost remain a major barrier.⁵³ Nevertheless, so far in the literature, only oxide ETLs have been studied for BaZrS₃-based chalcogenide perovskites, which sets the research gap. In recent years, sulfide ETLs emerged as a promising material owing to their exceptional photoelectric properties stemming from the valence electron shell structure within the 3d orbitals. Compared with oxide ETLs, metal sulfides offer many compelling advantages. To begin with, metal sulfides exhibit exceptional electron transport mobility, which serves as a catalyst for efficient charge extraction and transportation, effectively mitigating the risk of charge accumulation and recombination at the ETL/absorber interface. Moreover, they can be synthesized using low-temperature methods, underscoring their energy efficiency and compatibility with flexible substrates. Furthermore, metal sulfides distinguish themselves as wide band gap materials without oxygen vacancies, enhancing the device's optical stability. Indeed, the substantial

binding energy between metal sulfides and absorbers can effectively eliminate the ionic migration within the absorber, offering the pathway to elevate the overall performance and durability of devices.^{49,105}

To date, various sulfide ETLs such as MoS₂, WS₂, TiS₂, TaS₂, SnS₂, SnS, In₂S₃, Bi₂S₃, ZnS, and Sb₂S₃ have been investigated for lead halide perovskites, revealing their dominant characteristics over oxides.¹⁰⁵ Hence, it is interesting to investigate the suitability of new sulfide ETLs. In this concern, we have meticulously selected ZrS₂ ETL and examined its applicability for emerging BaZrS₃ chalcogenide perovskite devices, which creates opportunities for experimental scientists to explore the effectiveness of novel ZrS₂ ETLs in practice. Hence, we have performed comprehensive device engineering and accomplished PCEs of 32.58% (FTO/ZrS₂/Ba(Zr_{0.96},Ti_{0.04})S₃/SnS/Pt) and 28.17% (FTO/ZrS₂/BaZrS₃/SnS/Pt) which is the highest among the reported works. Thus, we firmly believe that our work will ignite the interest in the scientific community and provide a roadmap for experimentalists to fabricate highly efficient BaZrS₃ and Ba(Zr,Ti)S₃ chalcogenide perovskite devices.

4.1. Experimental Suggestions to Improve the Device Performance in Practice Based on Simulation Outcomes. Our study employed SCAPS-1D theoretical simulation to identify the most suitable device configuration for the new BaZrS₃ device. We propose the most effective device configurations of ZrS₂/BaZrS₃/SnS and ZrS₂/Ba(Zr,Ti)S₃/SnS, which offer impressive PCE of 28.17 and 32.58%, respectively. The optimization of essential parameters such as thickness, carrier concentration, and defect density of the ETL, absorber, and HTL are the key factors that led to high PCE values. However, it is essential to note that practical guidance for the successful fabrication of the devices is still necessary. In view of this, we have outlined various strategies to optimize the key parameters experimentally.

To start with, we found that ZrS₂, a transition-metal dichalcogenide semiconductor (TMDS), performs best when its influential parameters, such as carrier concentration (10¹⁹ cm⁻³) and defect density (10¹⁶ cm⁻³), are within the optimal range. Substitutional and chemical doping can increase the carrier concentration. External dopants like transition metals and halogens can replace metal or chalcogen sites in substitutional doping to boost the carrier concentration. Chemical doping, on the other hand, involves the adsorption of dopants onto the semiconductor surface without altering its structure. This process stimulates the surface charge transfer between the dopants and TMDS, improving carrier concentration and charge transfer properties. It is noteworthy that annealing with continuous electron beam irradiation has been explored as an alternative technique to improve the carrier concentration.⁵³ ZrS₂ is generally prone to sulfur defects, which can be rectified by a sulfur vapor annealing process to minimize defects and improve crystallinity.¹⁰⁹

As stated in Section 3.2, the BaZrS₃ absorber showed its best performance at an optimum thickness of 1000 nm. This can be achieved using various techniques such as vapor deposition, sputtering, and electrodeposition, which allow for better control over factors like film thickness, composition, purity, and uniformity by changing deposition conditions such as time, temperature, pressure, and potential.¹¹⁰ The film thickness can be increased by repeating the deposition time and annealing steps. Furthermore, Meng et al. reported that BaZrS₃ and Ba(Zr,Ti)S₃ films synthesized under S-rich/Zr-

poor conditions exhibit strong p-type behavior with an optimum carrier concentration of 10¹⁵ cm⁻³ and surpass the deep-level defects due to their high formation energy that results in lower defect density. However, films synthesized under S-poor/Zr-rich conditions possess n-type behavior with a high carrier concentration of >10¹⁷ cm⁻³, making them unsuitable for the absorber. Thus, it is necessary to adjust the elemental composition while synthesizing BaZrS₃ and Ba(Zr,Ti)S₃ films to obtain an optimum carrier concentration and reduce the formation of deep-level defects.³⁸

Interestingly, the highest PCEs of 28.17 and 32.58% were achieved with SnS as the HTL, indicating its suitability and appropriate band alignment with the absorber. However, the formation of impurity phases such as Sn₂S₃ and SnS₂ in SnS remains a significant drawback. To overcome this, Steinmann et al. reported that annealing SnS for 1 h under vacuum conditions (15 m Torr) at 500 °C or in an Ar or H₂ gas atmosphere at ambient temperature prevents the formation of impurity phases.¹¹¹ Moreover, introducing Sn excess composition (Sn_{1.05}S) during the synthesis process significantly reduces the formation of Sn₂S₃ without additional thermal processing.¹¹² In summary, the methods and strategies proposed have the potential to significantly benefit the PV community by enabling them to fabricate highly efficient BaZrS₃-based devices as technology advances.

5. CONCLUSIONS

In this work, we have comprehensively shed light on the device engineering of BaZrS₃ solar cells using SCAPS-1D numerical simulation. Initially, we optimized each layer (FTO/SnO₂/BaZrS₃/Cu₂S/Au) of the base device structure by varying its thickness, carrier concentration, and defect density. Thereafter, we altered the ETL and optimized it by keeping other layers constant. In the next step, by keeping the optimized conditions of ETL and absorber, we varied 13 HTLs and optimized it. This stepwise process was adopted to find the suitable device structure for the BaZrS₃ absorber. We modeled 782 devices by this approach, and 156 devices showed the best PCE for each ETL and HTL combination. Interestingly, the FTO/ZrS₂/BaZrS₃/SnS/Pt device demonstrated the highest PCE of 28.08%. This rotational selection of ETLs and HTLs resulted in the efficient collection of electrons and holes and gave desirable band offset, restricting the interfacial recombination and ideal band alignment, resulting in enhanced performance. Furthermore, the PCE of the device was enhanced to 28.17% after optimizing the metal contacts. In addition, the performance of BaZrS₃ was further improved by Ti alloying with 4 atom % and achieved a maximum theoretical PCE of 32.58% due to its extended absorption to the NIR region and less lattice mismatch compared with BaZrS₃. Our study provides a guiding rule for understanding the material properties and selecting cost-effective and efficient pin structures.

■ ASSOCIATED CONTENT

SI Supporting Information

The Supporting Information is available free of charge at <https://pubs.acs.org/doi/10.1021/acsomega.3c06627>.

Changes in the PV parameters as a function of ETL thickness, carrier concentration, and defect density; changes in the PV parameters for devices T1, T2, T3, and T4 as a function of absorber thickness, carrier concentration, and defect density; simulation parameters

for 12 ETLs and 13 HTLs; simulation parameters for devices T1, T2, T3, and T4; and device engineering of 782 chalcogenide perovskite devices (PDF)

AUTHOR INFORMATION

Corresponding Author

Latha Marasamy – Facultad de Química, Materiales-Energía, Universidad Autónoma de Querétaro, Santiago de Querétaro, Querétaro C.P. 76010, México; orcid.org/0000-0002-2564-0894; Email: latha.marasamy@uaq.mx

Authors

Eupsy Navis Vincent Mercy – Facultad de Química, Materiales-Energía, Universidad Autónoma de Querétaro, Santiago de Querétaro, Querétaro C.P. 76010, México

Dhineshkumar Srinivasan – Facultad de Química, Materiales-Energía, Universidad Autónoma de Querétaro, Santiago de Querétaro, Querétaro C.P. 76010, México

Complete contact information is available at:

<https://pubs.acs.org/10.1021/acsomega.3c06627>

Funding

This research did not receive any specific grant from funding agencies in the public, commercial, or not-for-profit sectors.

Notes

The authors declare no competing financial interest.

ACKNOWLEDGMENTS

The authors thank Marc Burgelman, ELSI, University of Gent, Belgium, for providing SCAPS-1D simulation software.

REFERENCES

- Zhang, J.; Gao, X.; Deng, Y.; Zha, Y.; Yuan, C. Comparison of Life Cycle Environmental Impacts of Different Perovskite Solar Cell Systems. *Sol. Energy Mater. Sol. Cells* **2017**, *166*, 9–17.
- Hoefler, S. F.; Trimmel, G.; Rath, T. Progress on Lead-Free Metal Halide Perovskites for Photovoltaic Applications: A Review. *Monatsh. Chem.* **2017**, *148*, 795–826.
- Nair, S.; Patel, S. B.; Gohel, J. V. Recent Trends in Efficiency-Stability Improvement in Perovskite Solar Cells. *Mater. Today Energy* **2020**, *17*, No. 100449.
- <https://www.nrel.gov/pv/cell-efficiency.html>.
- Wang, X.; Zhang, T.; Lou, Y.; Zhao, Y. All-Inorganic Lead-Free Perovskites for Optoelectronic Applications. *Mater. Chem. Front.* **2019**, *3* (3), 365–375.
- Hossain, M. K.; Samajdar, D. P.; Das, R. C.; Arnab, A. A.; Rahman, M. F.; Rubel, M. H. K.; Islam, M. R.; Bencherif, H.; Pandey, R.; Madan, J.; Mohammed, M. K. A. Design and Simulation of Cs₂BiAgI₆ Double Perovskite Solar Cells with Different Electron Transport Layers for Efficiency Enhancement. *Energy Fuels* **2023**, *37* (5), 3957–3979.
- Kalaph, K. A.; Jafar, A. M.; Abdalameer, N. K.; Hmood, A. M. A Review on Recent Advances in Materials of Hybrid Organic–Inorganic Perovskite Solar Cells. *IJOIR* **2022**, *9* (2), 148–158.
- Javaid, K.; Yu, J.; Wu, W.; Wang, J.; Zhang, H.; Gao, J.; Zhuge, F.; Liang, L.; Cao, H. Thin Film Solar Cell Based on ZnSnN₂/SnO Heterojunction. *Phys. Status Solidi RRL* **2018**, *12* (1), No. 1700332.
- Javaid, K.; Wu, W.; Wang, J.; Fang, J.; Zhang, H.; Gao, J.; Zhuge, F.; Liang, L.; Cao, H. Band Offset Engineering in ZnSnN₂-Based Heterojunction for Low-Cost Solar Cells. *ACS Photonics* **2018**, *5* (6), 2094–2099.
- Dunlap-Shohl, W. A.; Hill, I. G.; Yan, Y.; Mitzi, D. B. Photovoltaic Effect in Indium(I) Iodide Thin Films. *Chem. Mater.* **2018**, *30* (22), 8226–8232.
- Tiwari, D.; Alibhai, D.; Fermin, D. J. Above 600 MV Open-Circuit Voltage BiI₃ Solar Cells. *ACS Energy Lett.* **2018**, *3* (8), 1882–1886.
- Huang, P.-C.; Yang, W.-C.; Lee, M.-W. AgBiS₂ Semiconductor-Sensitized Solar Cells. *J. Phys. Chem. C* **2013**, *117* (36), 18308–18314.
- Patterson, R. J.; Xia, H.; Hu, L.; Zhang, Z.; Yuan, L.; Yang, J.; Chen, W.; Chen, Z.; Gao, Y.; Hu, Y.; Veettil, B. P.; Stride, J. A.; Conibeer, G.; Huang, S. Oxygen Substitution and Sulfur Vacancies in NaBiS₂: A Pb-Free Candidate for Solution Processable Solar Cells. In *2017 IEEE 44th Photovoltaic Specialist Conference (PVSC)*; IEEE, 2017; pp 2392–2394.
- Xia, Z.; Yu, F.-X.; Lu, S.-C.; Xue, D.-J.; He, Y.-S.; Yang, B.; Wang, C.; Ding, R.-Q.; Zhong, J.; Tang, J. Synthesis and Characterization of NaSbS₂ Thin Film for Potential Photodetector and Photovoltaic Application. *Chin. Chem. Lett.* **2017**, *28* (4), 881–887.
- Hoye, R. L. Z.; Lee, L. C.; Kurchin, R. C.; Huq, T. N.; Zhang, K. H. L.; Sponseller, M.; Nienhaus, L.; Brandt, R. E.; Jean, J.; Polizzotti, J. A.; Kursumović, A.; Bawendi, M. G.; Bulović, V.; Stevanović, V.; Buonassisi, T.; MacManus-Driscoll, J. L. Strongly Enhanced Photovoltaic Performance and Defect Physics of Air-Stable Bismuth Oxyiodide (BiOI). *Adv. Mater.* **2017**, *29* (36), No. 1702176.
- Tiwari, D.; Cardoso-Delgado, F.; Alibhai, D.; Mombrú, M.; Fermín, D. J. Photovoltaic Performance of Phase-Pure Orthorhombic BiSI Thin-Films. *ACS Appl. Energy Mater.* **2019**, *2* (5), 3878–3885.
- Yoo, B.; Ding, D.; Marin-Beloqui, J. M.; Lanzetta, L.; Bu, X.; Rath, T.; Haque, S. A. Improved Charge Separation and Photovoltaic Performance of BiI₃ Absorber Layers by Use of an In Situ Formed BiSI Interlayer. *ACS Appl. Energy Mater.* **2019**, *2* (10), 7056–7061.
- Choi, Y. C.; Hwang, E.; Kim, D.-H. Controlled Growth of SbSI Thin Films from Amorphous Sb₂S₃ for Low-Temperature Solution Processed Chalcogenide Solar Cells. *APL Mater.* **2018**, *6* (12), No. 121108.
- Nie, R.; Seok, S. II Efficient Antimony-Based Solar Cells by Enhanced Charge Transfer. *Small Methods* **2020**, *4* (2), No. 1900698.
- Nie, R.; Hu, M.; Risqi, A. M.; Li, Z.; Seok, S. II Efficient and Stable Antimony Selenoiodide Solar Cells. *Adv. Sci.* **2021**, *8* (8), No. 2003172.
- Nie, R.; Im, J.; Seok, S. I. Efficient Solar Cells Employing Light-Harvesting Sb_{0.67}Bi_{0.33}SI. *Adv. Mater.* **2019**, *31* (18), No. 1808344.
- Toso, S.; Akkerman, Q. A.; Martín-García, B.; Prato, M.; Zito, J.; Infante, I.; Dang, Z.; Moliterni, A.; Giannini, C.; Bladt, E.; Lobato, I.; Ramade, J.; Bals, S.; Buha, J.; Spirito, D.; Mugnaioli, E.; Gemmi, M.; Manna, L. Nanocrystals of Lead Chalcogenides: A Series of Kinetically Trapped Metastable Nanostructures. *J. Am. Chem. Soc.* **2020**, *142* (22), 10198–10211.
- Nie, R.; Kim, B.; Hong, S.-T.; Seok, S. II Nanostructured Heterojunction Solar Cells Based on Pb₂SbS₂I₃: Linking Lead Halide Perovskites and Metal Chalcogenides. *ACS Energy Lett.* **2018**, *3* (10), 2376–2382.
- Pai, N.; Lu, J.; Gengenbach, T. R.; Seeber, A.; Chesman, A. S. R.; Jiang, L.; Senevirathna, D. C.; Andrews, P. C.; Bach, U.; Cheng, Y.; Simonov, A. N. Silver Bismuth Sulfoiodide Solar Cells: Tuning Optoelectronic Properties by Sulfide Modification for Enhanced Photovoltaic Performance. *Adv. Energy Mater.* **2019**, *9* (5), No. 1803396.
- Nie, R.; Lee, K. S.; Hu, M.; Paik, M. J.; Seok, S. II Heteroleptic Tin-Antimony Sulfoiodide for Stable and Lead-Free Solar Cells. *Matter* **2020**, *3* (5), 1701–1713.
- Liu, H.; Xin, Z.; Cao, B.; Xu, Z.; Xu, B.; Zhu, Q.; Yang, J.; Zhang, B.; Fan, H. J. Polyhydroxylated Organic Molecular Additives for Durable Aqueous Zinc Battery. *Adv. Funct. Mater.* **2023**, No. 2309840.
- Zhang, C.; Teo, S.; Guo, Z.; Gao, L.; Kamata, Y.; Xu, Z.; Ma, T. Development of a Mixed Halide-Chalcogenide Bismuth-Based Perovskite MABi₂S with Small Bandgap and Wide Absorption Range. *Chem. Lett.* **2019**, *48* (3), 249–252.

- (28) Shin, D.; Zhu, T.; Huang, X.; Gunawan, O.; Blum, V.; Mitzi, D. B. Earth-Abundant Chalcogenide Photovoltaic Devices with over 5% Efficiency Based on a $\text{Cu}_2\text{BaSn}(\text{S},\text{Se})_4$ Absorber. *Adv. Mater.* **2017**, *29* (24), No. 1606945.
- (29) Crovetto, A.; Nielsen, R.; Stamate, E.; Hansen, O.; Seger, B.; Chorkendorff, I.; Vesborg, P. C. K. Wide Band Gap $\text{Cu}_2\text{SrSnS}_4$ Solar Cells from Oxide Precursors. *ACS Appl. Energy Mater.* **2019**, *2* (10), 7340–7344.
- (30) Spadaro, M. C.; Escobar Steinvall, S.; Dzade, N. Y.; Martí-Sánchez, S.; Torres-Vila, P.; Stutz, E. Z.; Zamani, M.; Paul, R.; Leran, J. B.; Fontcuberta I Morral, A.; Arbiol, J. Rotated Domains in Selective Area Epitaxy Grown Zn_3P_2 : Formation Mechanism and Functionality. *Nanoscale* **2021**, *13* (44), 18441–18450.
- (31) Paul, R.; Tabernig, S. W.; Reñé Saperia, J.; Hurni, J.; Tiede, A.; Liu, X.; Damry, D. A.; Conti, V.; Zamani, M.; Escobar Steinvall, S.; Dimitrievska, M.; Alarcon-Lladó, E.; Piazza, V.; Boland, J.; Haug, F. J.; Polman, A.; Fontcuberta i Morral, A. Carrier Generation and Collection in $\text{Zn}_3\text{P}_2/\text{InP}$ Heterojunction Solar Cells. *Sol. Energy Mater. Sol. Cells* **2023**, *256*, No. 112349.
- (32) Stutz, E. Z.; Ramanandan, S. P.; Flór, M.; Paul, R.; Zamani, M.; Escobar Steinvall, S.; Sandoval Salaiza, D. A.; Xifra Montesinos, C.; Spadaro, M. C.; Leran, J. B.; Litvinchuk, A. P.; Arbiol, J.; Fontcuberta i Morral, A.; Dimitrievska, M. Stoichiometry Modulates the Optoelectronic Functionality of Zinc Phosphide ($\text{Zn}_{3-x}\text{P}_{2+x}$). *Faraday Discuss.* **2022**, *239*, 202–218.
- (33) Sun, Y. Y.; Agiorgousis, M. L.; Zhang, P.; Zhang, S. Chalcogenide Perovskites for Photovoltaics. *Nano Lett.* **2015**, *15* (1), 581–585.
- (34) Sharma, S.; Ward, Z. D.; Bhimani, K.; Sharma, M.; Quinton, J.; Rhone, T. D.; Shi, S.-F.; Terrones, H.; Koratkar, N. Machine Learning-Aided Band Gap Engineering of BaZrS_3 Chalcogenide Perovskite. *ACS Appl. Mater. Interfaces* **2023**, *15* (15), 18962–18972.
- (35) Wei, X.; Hui, H.; Zhao, C.; Deng, C.; Han, M.; Yu, Z.; Sheng, A.; Roy, P.; Chen, A.; Lin, J.; Watson, D. F.; Sun, Y.-Y.; Thomay, T.; Yang, S.; Jia, Q.; Zhang, S.; Zeng, H. Realization of BaZrS_3 Chalcogenide Perovskite Thin Films for Optoelectronics. *Nano Energy* **2020**, *68*, No. 104317.
- (36) Han, Y.; Xu, J.; Liang, Y.; Chen, X.; Jia, M.; Zhang, J.; Lian, L.; Liu, Y.; Li, X.; Shi, Z. P-Type Conductive BaZrS_3 Thin Film and Its Band Gap Tuning via Ruddlesden-Popper $\text{Ba}_3\text{Zr}_2\text{S}_7$ and Titanium Alloying. *Chem. Eng. J.* **2023**, *473*, No. 145351.
- (37) Barman, B.; Ingole, S. Analysis of Si Back-Contact for Chalcogenide Perovskite Solar Cells Based on BaZrS_3 Using SCAPS-1D. *Adv. Theory Simul.* **2023**, *6*, No. 2200820.
- (38) Meng, W.; Saparov, B.; Hong, F.; Wang, J.; Mitzi, D. B.; Yan, Y. Alloying and Defect Control within Chalcogenide Perovskites for Optimized Photovoltaic Application. *Chem. Mater.* **2016**, *28* (3), 821–829.
- (39) Panikar Ramanandan, S.; Giunto, A.; Stutz, E. Z.; Xavier Marie Reyner, B.; Tiphaine Françoise Marie Lefevre, I.; Rusu, M.; Schorr, S.; Unold, T.; Fontcuberta Morral, A.; Márquez Prieto, J.; Dimitrievska, M. Understanding the Growth Mechanism of BaZrS_3 Chalcogenide Perovskite Thin Films from Sulfurized Oxide Precursors. *J. Phys. Energy* **2023**, No. 014013.
- (40) Comparotto, C.; Ström, P.; Donzel-Gargand, O.; Kubart, T.; Scragg, J. J. S. Synthesis of BaZrS_3 Perovskite Thin Films at a Moderate Temperature on Conductive Substrates. *ACS Appl. Energy Mater.* **2022**, *5*, 6335–6343.
- (41) Yu, Z.; Wei, X.; Zheng, Y.; Hui, H.; Bian, M.; Dhole, S.; Seo, J. H.; Sun, Y. Y.; Jia, Q.; Zhang, S.; Yang, S.; Zeng, H. Chalcogenide Perovskite BaZrS_3 Thin-Film Electronic and Optoelectronic Devices by Low Temperature Processing. *Nano Energy* **2021**, *85*, No. 105959.
- (42) Yang, R.; Jess, A. D.; Fai, C.; Hages, C. J. Low-Temperature, Solution-Based Synthesis of Luminescent Chalcogenide Perovskite BaZrS_3 Nanoparticles. *J. Am. Chem. Soc.* **2022**, *144*, 15928–15931.
- (43) Zilevu, D.; Parks, O. O.; Creutz, S. E. Solution-Phase Synthesis of the Chalcogenide Perovskite Barium Zirconium Sulfide as Colloidal Nanomaterials. *Chemical Communications* **2022**, *58* (75), 10512–10515.
- (44) Vincent, K. C.; Agarwal, S.; Turnley, J. W.; Agrawal, R. Liquid Flux-Assisted Mechanism for Modest Temperature Synthesis of Large-Grain BaZrS_3 and BaHfS_3 Chalcogenide Perovskites. *Adv. Energy Sustainability Res.* **2023**, *4* (5), No. 2300010, DOI: 10.1002/aesr.202300010.
- (45) Khattak, Y. H.; Baig, F.; Shuja, A.; Atourki, L.; Riaz, K.; Soucase, B. M. Device Optimization of PIN Structured Perovskite Solar Cells: Impact of Design Variants. *ACS Appl. Electron Mater.* **2021**, *3* (8), 3509–3520.
- (46) Karthick, S.; Velumani, S.; Bouclé, J. Experimental and SCAPS Simulated Formamidinium Perovskite Solar Cells: A Comparison of Device Performance. *Sol. Energy* **2020**, *205*, 349–357.
- (47) Karthick, S.; Velumani, S.; Bouclé, J. Chalcogenide BaZrS_3 Perovskite Solar Cells: A Numerical Simulation and Analysis Using SCAPS-1D. *Opt. Mater.* **2022**, *126*, No. 112250, DOI: 10.1016/j.optmat.2022.112250.
- (48) Chawki, N.; Rouchdi, M.; Fares, B. Numerical Study of BaZrS_3 Based Chalcogenide Perovskite Solar Cell Using SCAPS-1D Device Simulation **2022** DOI: 10.21203/rs.3.rs-1251663/v1.
- (49) Mohamad Noh, M. F.; Teh, C. H.; Daik, R.; Lim, E. L.; Yap, C. C.; Ibrahim, M. A.; Ahmad Ludin, N.; Mohd Yusoff, A. R. B.; Jang, J.; Mat Teridi, M. A. The Architecture of the Electron Transport Layer for a Perovskite Solar Cell. *J. Mater. Chem. C* **2018**, *6*, 682–712.
- (50) Cheng, M.; Zuo, C.; Wu, Y.; Li, Z.; Xu, B.; Hua, Y.; Ding, L. Charge-Transport Layer Engineering in Perovskite Solar Cells. *Sci. Bull.* **2020**, *65*, 1237–1241.
- (51) Capistrán-Martínez, J.; Loeza-Díaz, D.; Mora-Herrera, D.; Pérez-Rodríguez, F.; Pal, M. Theoretical Evaluation of Emerging Cd-Free Cu_3BiS_3 Based Solar Cells Using Experimental Data of Chemically Deposited Cu_3BiS_3 Thin Films. *J. Alloys Compd.* **2021**, *867*, No. 159156.
- (52) Linhart, W. M.; Zelewski, S. J.; Scharoch, P.; Dybala, F.; Kudrawiec, R. Nesting-like Band Gap in Bismuth Sulfide Bi_2S_3 . *J. Mater. Chem. C* **2021**, *9* (39), 13733–13738.
- (53) Arockiya-Dass, K. T.; Sekar, K.; Marasamy, L. Theoretical Insights of Degenerate ZrS_2 as a New Buffer for Highly Efficient Emerging Thin-Film Solar Cells. *Energy Technol.* **2023**, *11* (9), No. 2300333.
- (54) Li, Y.; Kang, J.; Li, J. Indirect-to-Direct Band Gap Transition of the ZrS_2 Monolayer by Strain: First-Principles Calculations. *RSC Adv.* **2014**, *4* (15), 7396–7401.
- (55) Pansuriya, T.; Malani, R.; Kheraj, V. Investigations on the Effect of Buffer Layer on CMTS Based Thin Film Solar Cell Using SCAPS 1-D. *Opt. Mater.* **2022**, *126*, No. 112150.
- (56) Oyedele, S. O.; Aka, B. Numerical Simulation of Varied Buffer Layer of Solar Cells Based on CIGS. *Model. Numer. Simul. Mater. Sci.* **2017**, *07* (03), 33–45.
- (57) Rassol, R. A.; Hasan, R. F.; Ahmed, S. M. Numerical Analysis of $\text{SnO}_2/\text{Zn}_2\text{SnO}_4/\text{n-CdS/p-CdTe}$ Solar Cell Using the SCAPS-1D Simulation Software. *Iraqi J. Sci.* **2021**, *505*–516.
- (58) Rahman, A. Design and Simulation of High-Performance Planar Npp^+ Heterojunction $\text{CH}_3\text{NH}_3\text{PbI}_3$ Based Perovskite Solar Cells Using BaSnO_3 ETM and Cu_2O HTM. **2021**.
- (59) Chihi, A.; Boujmil, M. F.; Bessais, B. Investigation on the Performance of CIGS/ TiO_2 Heterojunction Using SCAPS Software for Highly Efficient Solar Cells. *J. Electron. Mater.* **2017**, *46* (8), 5270–5277.
- (60) Filatova, E. O.; Konashuk, A. S. Interpretation of the Changing the Band Gap of Al_2O_3 Depending on Its Crystalline Form: Connection with Different Local Symmetries. *J. Phys. Chem. C* **2015**, *119* (35), 20755–20761.
- (61) Ahmed, S.; Jannat, F.; Khan, Md. A. K.; Alim, M. A. Numerical Development of Eco-Friendly Cs_2TiBr_6 Based Perovskite Solar Cell with All-Inorganic Charge Transport Materials via SCAPS-1D. *Optik* **2021**, *225*, No. 165765.
- (62) Elseman, A. M.; Sajid, S.; Shalan, A. E.; Mohamed, S. A.; Rashad, M. M. Recent Progress Concerning Inorganic Hole Transport Layers for Efficient Perovskite Solar Cells. *Appl. Phys. A*: **2019**, *125*, No. 476.

- (63) Kohnehpoushi, S.; Nazari, P.; Nejand, B. A.; Eskandari, M. MoS_2 : A Two-Dimensional Hole-Transporting Material for High-Efficiency, Low-Cost Perovskite Solar Cells. *Nanotechnology* **2018**, *29* (20), No. 205201.
- (64) Sawicka-Chudy, P.; Sibiński, M.; Wisz, G.; Rybak-Wilusz, E.; Cholewa, M. Numerical Analysis and Optimization of $\text{Cu}_2\text{O}/\text{TiO}_2/\text{CuO}/\text{TiO}_2$ Heterojunction Solar Cells Using SCAPS. *J. Phys. Conf. Ser.* **2018**, *1033*, No. 012002.
- (65) Wells, B. Nanostructured Device Designs for Enhanced Performance in $\text{CdS}/\text{Cu}_2\text{S}$ Heterojunction Solar Cells **2020** DOI: 10.13023/etd.2020.166.
- (66) Livingston, L. M. M.; Raj, A. G. S.; Prabu, R. T.; Kumar, A. Computational Analysis of FeS_2 Material for Solar Cell Application. *Opt. Quantum Electron.* **2023**, *55* (3), No. 244.
- (67) Basak, A.; Singh, U. P. Numerical Modelling and Analysis of Earth Abundant Sb_2S_3 and Sb_2Se_3 Based Solar Cells Using SCAPS-1D. *Sol. Energy Mater. Sol. Cells* **2021**, *230*, No. 111184.
- (68) Minbashi, M.; Ghobadi, A.; Ehsani, M. H.; Rezagholipour Dizaji, H.; Memarian, N. Simulation of High Efficiency SnS -Based Solar Cells with SCAPS. *Sol. Energy* **2018**, *176*, 520–525.
- (69) Capistrán-Martínez, J.; Loeza-Díaz, D.; Mora-Herrera, D.; Pérez-Rodríguez, F.; Pal, M. Theoretical Evaluation of Emerging Cd-Free Cu_3BiS_3 Based Solar Cells Using Experimental Data of Chemically Deposited Cu_3BiS_3 Thin Films. *J. Alloys Compd.* **2021**, *867*, No. 159156.
- (70) Amiri, I. S.; Ahmad, H.; Ariannejad, M. M.; Ismail, M. F.; Thambiratnam, K.; Yasin, M.; Nik Abdul-Aziz, N. M. A. Performance Analysis of Copper Tin Sulfide, Cu_2SnS_3 (CTS) with Various Buffer Layers by Using SCAPS in Solar Cells. *Surf. Rev. Lett.* **2017**, *24* (06), No. 1750073.
- (71) Devi, C.; Mehra, R. Device Simulation of Lead-Free MASn_3 Solar Cell with CuSbS_2 (Copper Antimony Sulfide). *J. Mater. Sci.* **2019**, *54* (7), 5615–5624.
- (72) Ghobadi, A.; Yousefi, M.; Minbashi, M.; Kordbacheh, A. H. A.; Abdolvahab, A. R. H.; Gorji, N. E. Simulating the Effect of Adding BSF Layers on $\text{Cu}_2\text{BaSnSe}_3$ Thin Film Solar Cells. *Opt. Mater.* **2020**, *107*, No. 109927.
- (73) Ashraf, M. A.; Alam, I. Numerical Simulation of CIGS, CISSe and CZTS-Based Solar Cells with In_2S_3 as Buffer Layer and Au as Back Contact Using SCAPS 1D. *Eng. Res. Express.* **2020**, *2* (3), No. 035015.
- (74) Adewoyin, A. D.; Olopade, M. A.; Oyebola, O. O.; Chendo, M. A. Development of CZTGS/CZTS Tandem Thin Film Solar Cell Using SCAPS-1D. *Optik* **2019**, *176*, 132–142.
- (75) Wei, X.; Hui, H.; Perera, S.; Sheng, A.; Watson, D. F.; Sun, Y. Y.; Jia, Q.; Zhang, S.; Zeng, H. Ti-Alloying of BaZrS_3 Chalcogenide Perovskite for Photovoltaics. *ACS Omega* **2020**, *5* (30), 18579–18583.
- (76) Sobayel, K.; Shahinuzzaman, M.; Amin, N.; Karim, M. R.; Dar, M. A.; Gul, R.; Alghoul, M. A.; Sopian, K.; Hasan, A. K. M.; Akhtaruzzaman, M. Efficiency Enhancement of CIGS Solar Cell by WS_2 as Window Layer through Numerical Modelling Tool. *Sol. Energy* **2020**, *207*, 479–485.
- (77) Islam, M. S.; Islam, M. T.; Sarker, S.; Jame, H. Al; Nishat, S. S.; Jani, M. R.; Rauf, A.; Ahsan, S.; Shorowordi, K. M.; Efstathiadis, H.; Carbonara, J.; Ahmed, S. Machine Learning Approach to Delineate the Impact of Material Properties on Solar Cell Device Physics. *ACS Omega* **2022**, *7* (26), 22263–22278.
- (78) Mabvuer, F. T.; Nya, F. T.; Dzifack Kenfack, G. M.; Laref, A. Lowering Cost Approach for CIGS-Based Solar Cell Through Optimizing Band Gap Profile and Doping of Stacked Active Layers—SCAPS Modeling. *ACS Omega* **2023**, *8* (4), 3917–3928.
- (79) Regmi, G.; Ashok, A.; Chawla, P.; Semalti, P.; Velumani, S.; Sharma, S. N.; Castaneda, H. Perspectives of Chalcopyrite-Based CIGSe Thin-Film Solar Cell: A Review. *J. Mater. Sci. Mater. Electron* **2020**, *31*, 7286–7314.
- (80) Alipour, H.; Ghadimi, A. Optimization of Lead-Free Perovskite Solar Cells in Normal-Structure with WO_3 and Water-Free PEDOT:PSS Composite for Hole Transport Layer by SCAPS-1D Simulation. *Opt. Mater.* **2021**, *120*, No. 111432.
- (81) Rassol, R. A.; Hasan, R. F.; Ahmed, S. M. Numerical Analysis of $\text{SnO}_2/\text{Zn}_2\text{SnO}_4/\text{n-CdS}/\text{p-CdTe}$ Solar Cell Using the SCAPS-1D Simulation Software. *Iraqi J. Sci.* **2021**, *62* (2), 505–516.
- (82) Tousif, M. N.; Mohamma, S.; Ferdous, A. A.; Hoque, M. A. Investigation of Different Materials as Buffer Layer in CZTS Solar Cells Using SCAPS. *JOCET* **2018**, *6* (4), 293–296.
- (83) Mushtaq, S.; Tahir, S.; Ashfaq, A.; Sebastian Bonilla, R.; Haneef, M.; Saeed, R.; Ahmad, W.; Amin, N. Performance Optimization of Lead-Free MASnBr_3 Based Perovskite Solar Cells by SCAPS-1D Device Simulation. *Sol. Energy* **2023**, *249*, 401–413.
- (84) Pandey, R.; Bhattarai, S.; Sharma, K.; Madan, J.; Al-Mousoi, A. K.; Mohammed, M. K. A.; Hossain, M. K. Halide Composition Engineered a Non-Toxic Perovskite–Silicon Tandem Solar Cell with 30.7% Conversion Efficiency. *ACS Appl. Electron Mater.* **2023**, *5*, 5303–5315.
- (85) Hossain, M. K.; Toki, G. F. I.; Alam, I.; Pandey, R.; Samajdar, D. P.; Rahman, Md. F.; Islam, Md. R.; Rubel, M. H. K.; Bencherif, H.; Madan, J.; Mohammed, M. K. A. Numerical Simulation and Optimization of a CsPbI_3 -Based Perovskite Solar Cell to Enhance the Power Conversion Efficiency. *New J. Chem.* **2023**, *47* (10), 4801–4817.
- (86) Hossain, M. K.; Rubel, M. H. K.; Toki, G. F. I.; Alam, I.; Rahman, Md. F.; Bencherif, H. Effect of Various Electron and Hole Transport Layers on the Performance of CsPbI_3 -Based Perovskite Solar Cells: A Numerical Investigation in DFT, SCAPS-1D, and WxAMPS Frameworks. *ACS Omega* **2022**, *7* (47), 43210–43230.
- (87) Bag, A.; Radhakrishnan, R.; Nekoei, R.; Jeyakumar, R. Effect of Absorber Layer, Hole Transport Layer Thicknesses, and Its Doping Density on the Performance of Perovskite Solar Cells by Device Simulation. *Sol. Energy* **2020**, *196*, 177–182.
- (88) Ali, M. H.; Al Mamun, M. A.; Haque, M. D.; Rahman, M. F.; Hossain, M. K.; Md. Touhidul Islam, A. Z. Performance Enhancement of an MoS_2 -Based Heterojunction Solar Cell with an In_2Te_3 Back Surface Field: A Numerical Simulation Approach. *ACS Omega* **2023**, *8* (7), 7017–7029.
- (89) Chawki, N.; Rouchdi, M.; Fares, B. Numerical Study of BaZrS_3 Based Chalcogenide Perovskite Solar Cell Using SCAPS-1D Device Simulation. **2022**. DOI: 10.21203/rs.3.rs-1251663/v1.
- (90) Kim, G.-W.; Shinde, D. V.; Park, T. Thickness of the Hole Transport Layer in Perovskite Solar Cells: Performance versus Reproducibility. *RSC Adv.* **2015**, *5* (120), 99356–99360.
- (91) Jannat, F.; Ahmed, S.; Alim, M. A. Performance Analysis of Cesium Formamidinium Lead Mixed Halide Based Perovskite Solar Cell with MoOx as Hole Transport Material via SCAPS-1D. *Optik* **2021**, *228*, No. 166202.
- (92) Ahmad, O.; Rashid, A.; Ahmed, M. W.; Nasir, M. F.; Qasim, I. Performance Evaluation of $\text{Au}/\text{p-CdTe}/\text{Cs}_2\text{TiF}_6/\text{n-TiO}_2/\text{ITO}$ Solar Cell Using SCAPS-1D. *Opt. Mater.* **2021**, *117*, No. 111105.
- (93) Gamal, N.; Sedky, S. H.; Shaker, A.; Fedawy, M. Design of Lead-Free Perovskite Solar Cell Using $\text{Zn}_{1-x}\text{Mg}_x\text{O}$ as ETL: SCAPS Device Simulation. *Optik* **2021**, *242*, No. 167306.
- (94) Ali, M. H.; Al Mamun, M. A.; Haque, M. D.; Rahman, M. F.; Hossain, M. K.; Abu, A. Z. Performance Enhancement of an MoS_2 -Based Heterojunction Solar Cell with an In_2Te_3 Back Surface Field: A Numerical Simulation Approach. *ACS Omega* **2023**, *8* (7), 7017–7029.
- (95) Mozaffari, N.; Walter, D.; White, T. P.; Bui, A. D.; Tabi, G. D.; Weber, K.; Catchpole, K. R. Unraveling the Role of Energy Band Alignment and Mobile Ions on Interfacial Recombination in Perovskite Solar Cells. *Sol. RRL* **2022**, *6* (6), No. 2101087.
- (96) Ding, C.; Zhang, Y.; Liu, F.; Kitabatake, Y.; Hayase, S.; Toyoda, T.; Yoshino, K.; Minemoto, T.; Katayama, K.; Shen, Q. Effect of the Conduction Band Offset on Interfacial Recombination Behavior of the Planar Perovskite Solar Cells. *Nano Energy* **2018**, *53*, 17–26.
- (97) Orazem, M. E. Electron and Hole Transport in Degenerate Semiconductors. *AIChE J.* **1986**, *32* (5), 765–772.

- (98) Sandberg, O. J.; Kurpiers, J.; Stolterfoht, M.; Neher, D.; Meredith, P.; Shoaee, S.; Armin, A. On the Question of the Need for a Built-In Potential in Perovskite Solar Cells. *Adv. Mater. Interfaces* **2020**, *7* (10), No. 2000041.
- (99) Sharma, S.; Ward, Z.; Bhimani, K.; Li, K.; Lakhnot, A.; Jain, R.; Shi, S. F.; Terrones, H.; Koratkar, N. Bandgap Tuning in BaZrS₃ Perovskite Thin Films. *ACS Appl. Electron Mater.* **2021**, *3* (8), 3306–3312.
- (100) Welch, A. W.; Baranowski, L. L.; Peng, H.; Hempel, H.; Eichberger, R.; Unold, T.; Lany, S.; Wolden, C.; Zakutayev, A. Trade-Offs in Thin Film Solar Cells with Layered Chalcostibite Photovoltaic Absorbers. *Adv. Energy Mater.* **2017**, *7* (11), No. 1601935.
- (101) Ghafari, A.; Janowitz, C. Electronic and Thermoelectric Properties of ZrS_xSe_{2-x}. *Comput. Mater. Sci.* **2019**, *169*, No. 109109.
- (102) Andrade-Arvizu, J. A.; Courel-Piedrahita, M.; Vigil-Galán, O. SnS-Based Thin Film Solar Cells: Perspectives over the Last 25 Years. *J. Mater. Sci. Mater. Electron* **2015**, *26* (7), 4541–4556.
- (103) Rombach, F. M.; Haque, S. A.; Macdonald, T. J. Lessons Learned from Spiro-OMeTAD and PTAA in Perovskite Solar Cells. *Energy Environ. Sci.* **2021** 145161–5190.
- (104) Kakavelakis, G.; Gouda, L.; Tischler, Y.; Kaliakatsos, I.; Petridis, K. 2D Transition Metal Dichalcogenides for Solution-Processed Organic and Perovskite Solar Cells. In *Two Dimensional Transition Metal Dichalcogenides*; Springer: Singapore, 2019; pp 203–239.
- (105) He, Z.; Zhou, Y.; Liu, A.; Gao, L.; Zhang, C.; Wei, G.; Ma, T. Recent Progress in Metal Sulfide-Based Electron Transport Layers in Perovskite Solar Cells. *Nanoscale* **2021**, *13*, 17272–17289.
- (106) Goutham Kumar, S.; Pramod, A.; Prashanth, C. R.; Honnavar, G. V. Proposal for a Novel Perovskite Solar Cell Based on BaZrS₃ with Optimized Electron and Hole Transport Layer Using SCAPS-1D. *Eur. Chem. Bull.* **2023**, *12* (10), 10289–10307.
- (107) Thakur, N.; Kumar, P.; Neffati, R.; Sharma, P. Design and Simulation of Chalcogenide Perovskite BaZr(S,Se)₃ Compositions for Photovoltaic Applications. *Phys. Scr.* **2023**, *98* (6), No. 065921.
- (108) Kanoun, M. B.; Ul Haq, B.; Kanoun, A.-A.; Goumri-Said, S. Ti Alloying as a Route to BaZrS₃ Chalcogenide Perovskite with Enhanced Photovoltaic Performance. *Energy Fuels* **2023**, *37* (13), 9548–9556.
- (109) Otomo, M.; Hamada, M.; Ono, R.; Muneta, I.; Kakushima, K.; Tsutsui, K.; Wakabayashi, H. Chemical States of PVD-ZrS₂ Film underneath Scaled High-k Film with Self-Oxidized ZrO₂ Film as Interfacial Layer. *Jpn. J. Appl. Phys.* **2023**, *62*, No. SC1015.
- (110) Thakur, N.; Aly, K. A.; Mohery, M.; Ebrahim, M. M.; Kumar, P.; Sharma, P. Recent Advances in BaZrS₃ Perovskites: Synthesis, Properties, and Future Trends. *J. Alloys Compd.* **2023**, *957*, No. 170457.
- (111) Spalatu, N.; Hiie, J.; Kaupmees, R.; Volobujeva, O.; Krustok, J.; Acik, I. O.; Krunks, M. Postdeposition Processing of SnS Thin Films and Solar Cells: Prospective Strategy to Obtain Large, Sintered, and Doped SnS Grains by Recrystallization in the Presence of a Metal Halide Flux. *ACS Appl. Mater. Interfaces* **2019**, *11* (19), 17539–17554.
- (112) Park, B. I.; Jang, Y. H.; Lee, S. Y.; Lee, D. K. Mechanochemically Synthesized SnS Nanocrystals: Impact of Nonstoichiometry on Phase Purity and Solar Cell Performance. *ACS Sustainable Chem. Eng.* **2018**, *6* (3), 3002–3009.